

SEMICONDUCTOR DEVICES

Carrier Statistics

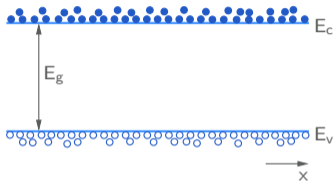


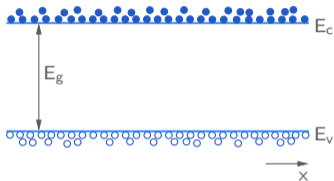
M. B. Patil

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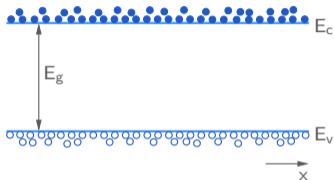
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Department of Electrical Engineering
Indian Institute of Technology Bombay

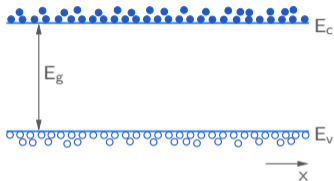




- * The term “carrier” refers to mobile entities, viz., electrons in the conduction band (or simply “electrons”) and vacancies in the valence band (or simply “holes”).

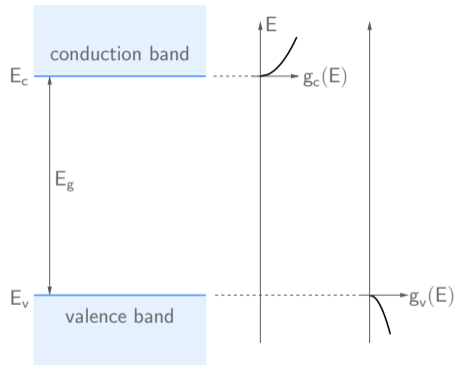


- * The term “carrier” refers to mobile entities, viz., electrons in the conduction band (or simply “electrons”) and vacancies in the valence band (or simply “holes”).
- * We are interested in the carrier densities, i.e., electron density (n) and hole density (p), because they are responsible for carrying a current. (The nuclei and core electrons of the silicon atoms do not contribute to conduction.)



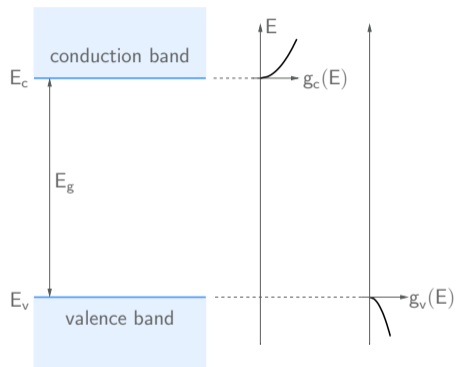
- * The term “carrier” refers to mobile entities, viz., electrons in the conduction band (or simply “electrons”) and vacancies in the valence band (or simply “holes”).
- * We are interested in the carrier densities, i.e., electron density (n) and hole density (p), because they are responsible for carrying a current. (The nuclei and core electrons of the silicon atoms do not contribute to conduction.)
- * We will first consider a semiconductor in equilibrium, i.e., without an external perturbation such as an applied voltage, a magnetic field, or optical illumination.

Electron density (n) in equilibrium



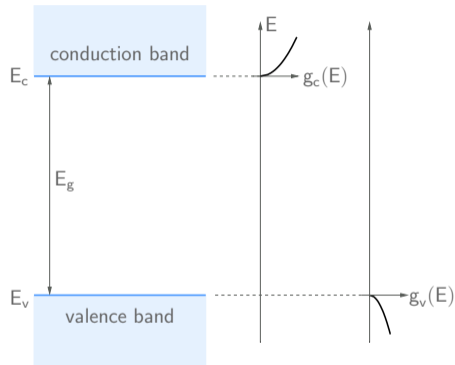
Electron density (n) in equilibrium

- * The electron density depends on two factors:



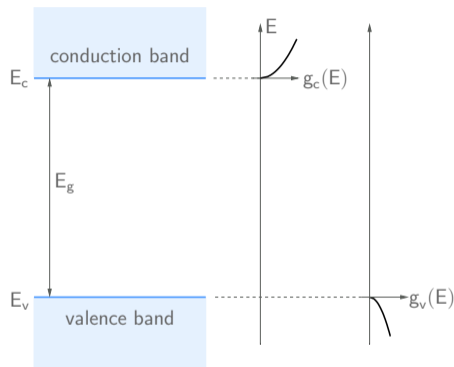
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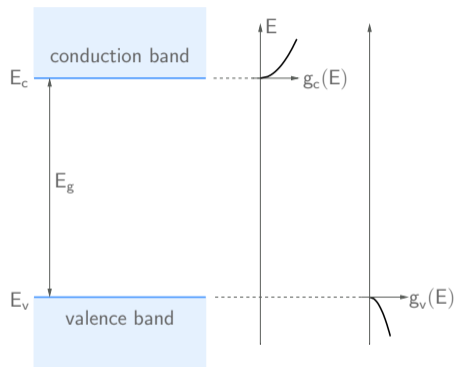
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- * The “density of states” function $g_c(E)$ gives the number of states available per unit energy per unit volume.



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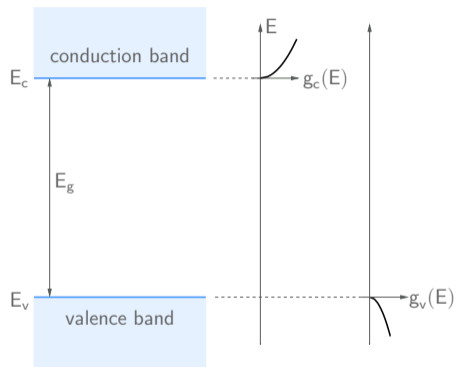
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- * The “density of states” function $g_c(E)$ gives the number of states available per unit energy per unit volume.

$$g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}, \quad E > E_c, \text{ where}$$

$m_n^* \equiv$ electron effective mass = $1.08 m_0$ for silicon at $T = 300$ K,

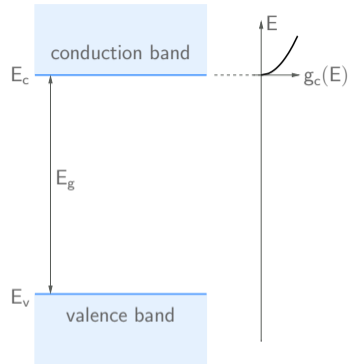
$m_0 =$ free electron mass = 9.1×10^{-31} Kg,

$\hbar = h/2\pi$, with h (Planck constant) = 6.63×10^{-34} J-s.



Electron density (n) in equilibrium

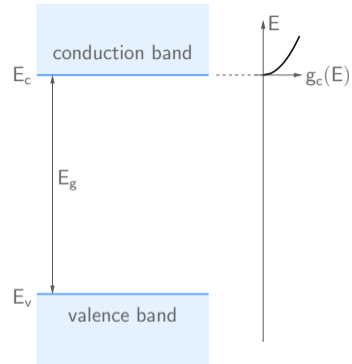
Calculate the number of states N' between E_c and $E_c + 50$ meV for silicon at $T = 300$ K.



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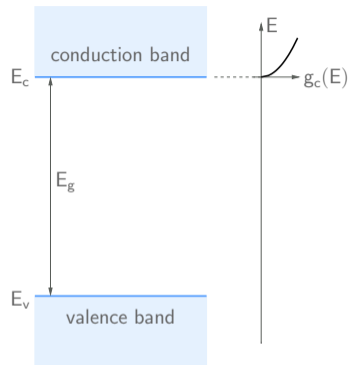
$$N' = \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE$$



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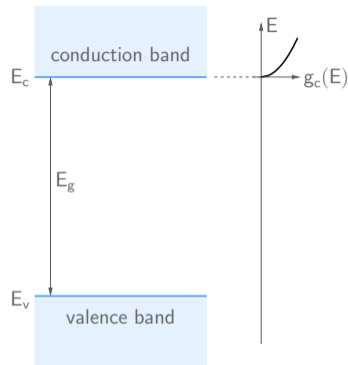
$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2}}{\pi^2 \hbar^3} \frac{(\Delta E)^{3/2}}{3/2} \end{aligned}$$



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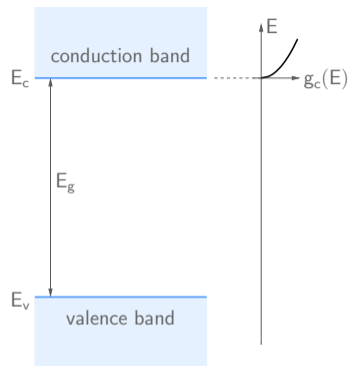
$$\begin{aligned} N' &= \int_{E_c}^{E_c + \Delta E} \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3} dE \\ &= \frac{\sqrt{2} (m_n^*)^{3/2} (\Delta E)^{3/2}}{\pi^2 \hbar^3} \frac{3/2}{3/2} \\ &= \frac{16\sqrt{2} \pi}{3} \left(\frac{m_n^* \Delta E}{h^2} \right)^{3/2} \end{aligned}$$



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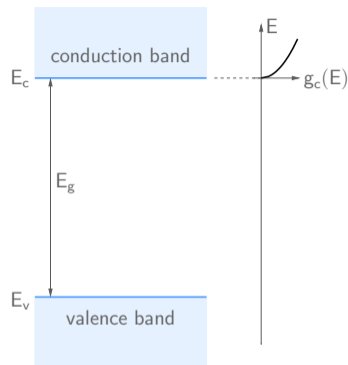
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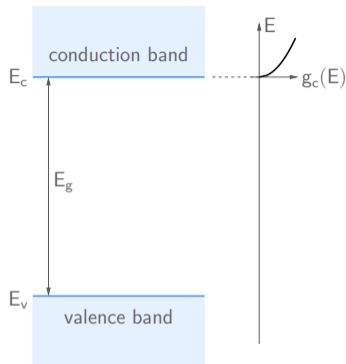


Electron density (n) in equilibrium

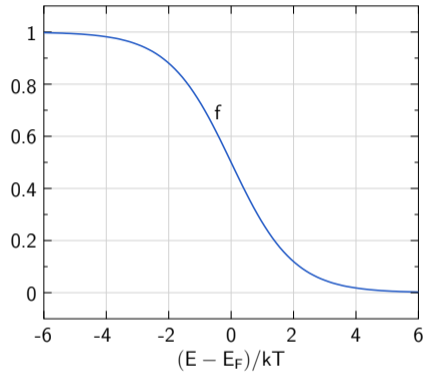
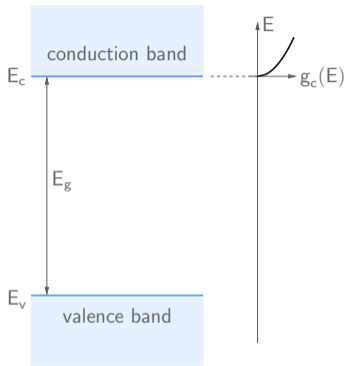
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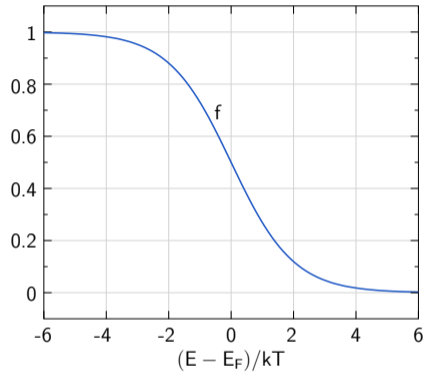
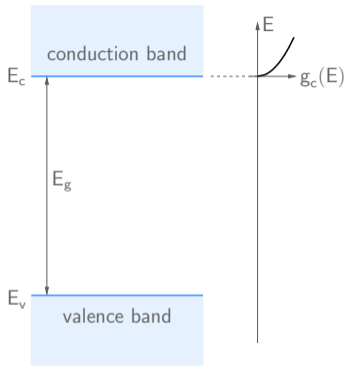
N' would be the number of electrons per unit volume (in the conduction band) if the states in the range $E_c < E < E_c + \Delta E$ were *all* occupied (and the rest of the states unoccupied). The real picture is different.



Electron density (n) in equilibrium

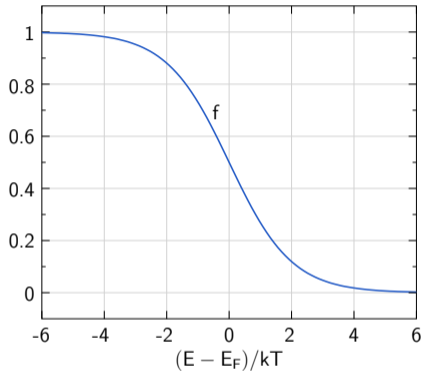
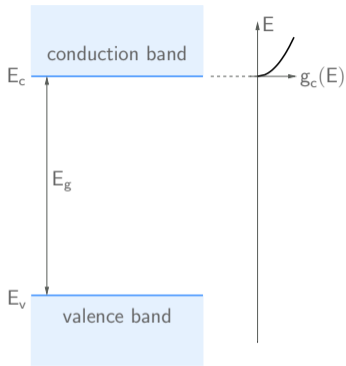


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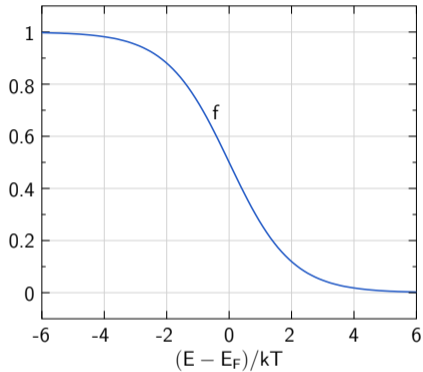
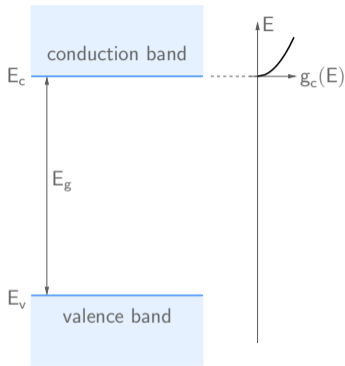
- * The number of electrons in the interval E to $(E + dE)$ is not $g_c(E)dE$ but $g_c(E)f(E)dE$.

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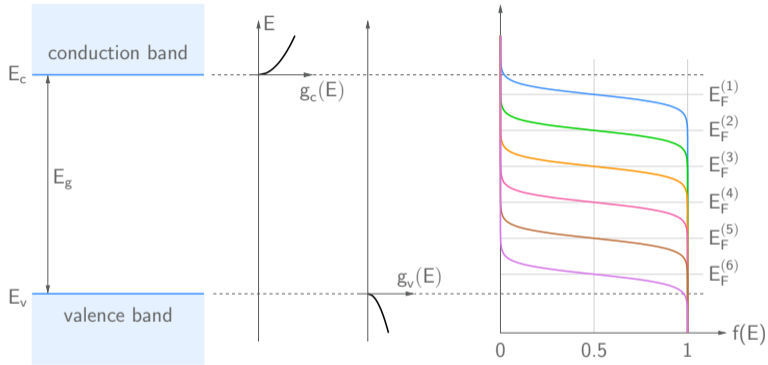
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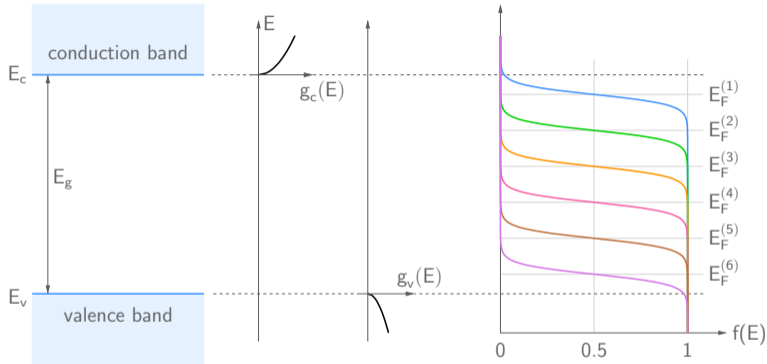


- * The number of electrons in the interval E to $(E + dE)$ is not $g_c(E)dE$ but $g_c(E)f(E)dE$.
- * $f(E)$ is the probability that the state at E is occupied.
- * The probability depends on the “Fermi level” E_F which typically lies in the forbidden gap.

Electron density (n) in equilibrium

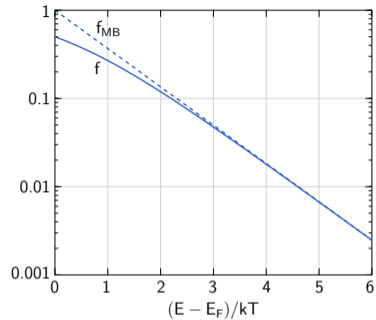
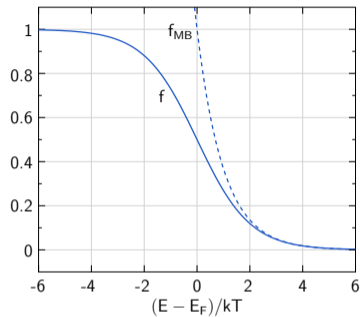
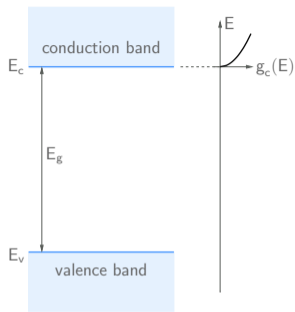


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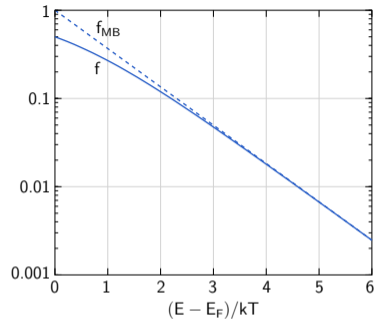
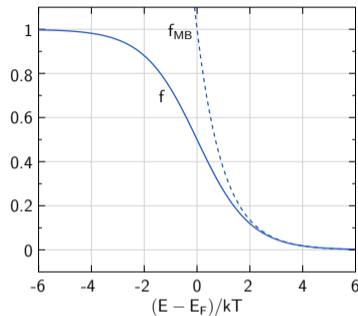
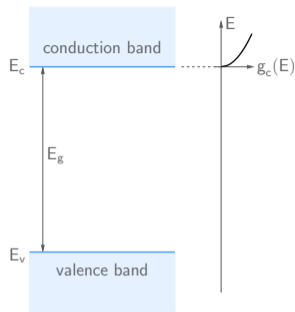


- * A change in the Fermi level causes the probability function to shift, and therefore the carrier concentrations (n and p) change substantially with E_F .

Electron density (n) in equilibrium

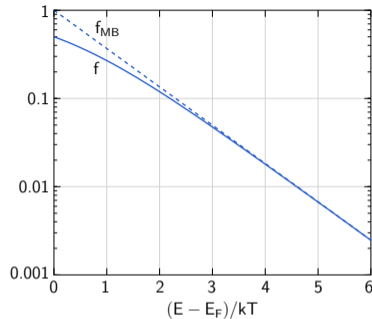
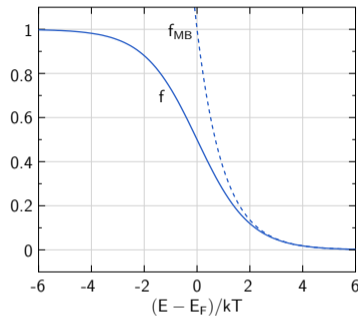
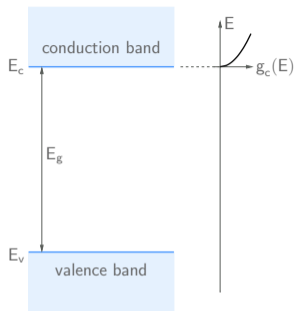


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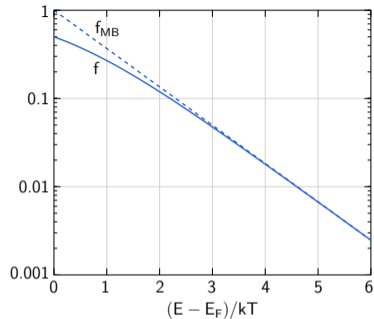
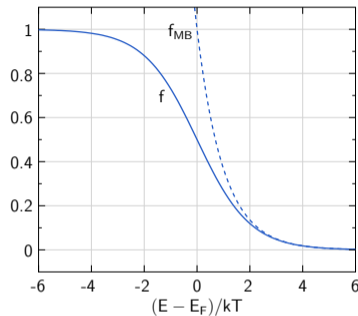
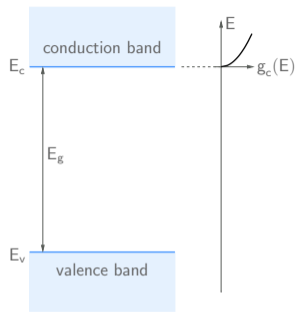
* $f(E)$ is given by the Fermi function: $f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$ where $k = 1.38 \times 10^{-23}$ J/K (or 8.62×10^{-5} eV/K) is the Boltzmann constant.

Electron density (n) in equilibrium



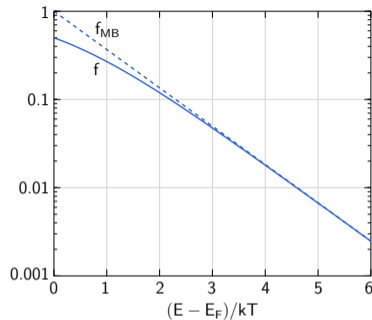
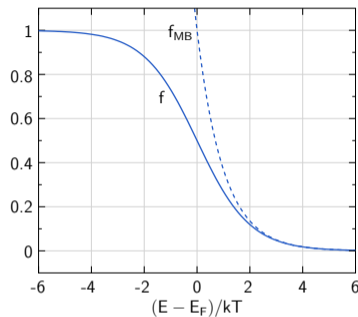
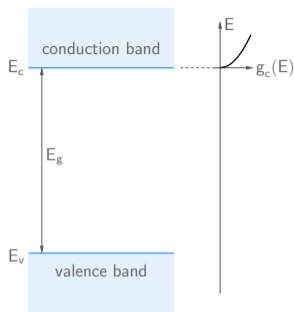
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Electron density (n) in equilibrium



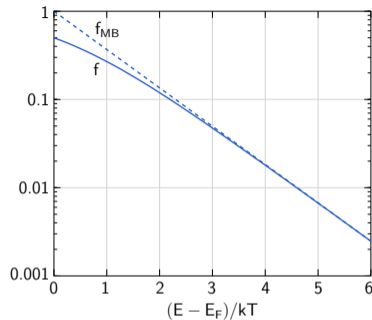
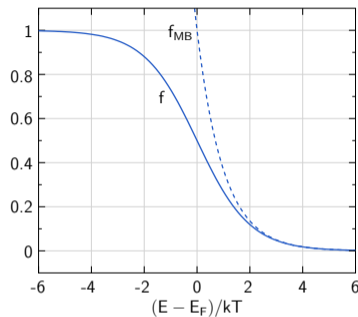
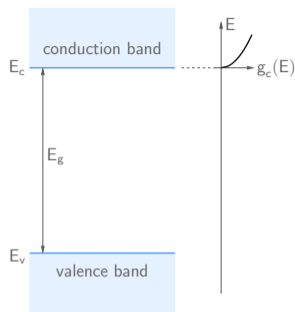
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- * At $E = E_F$, $f(E) = 1/2$.
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Electron density (n) in equilibrium



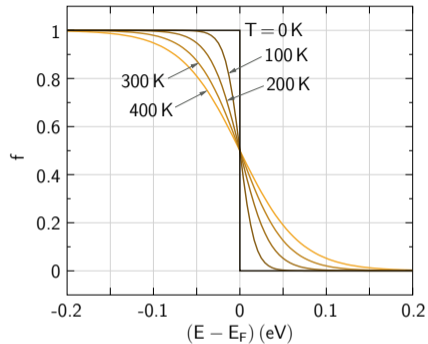
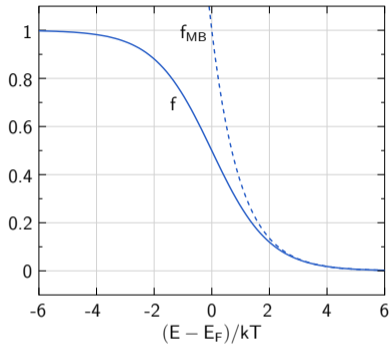
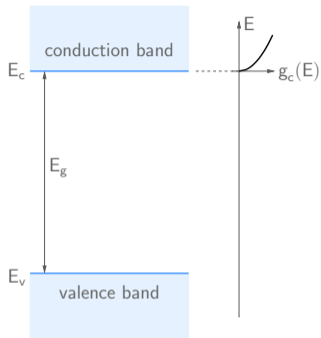
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Electron density (n) in equilibrium

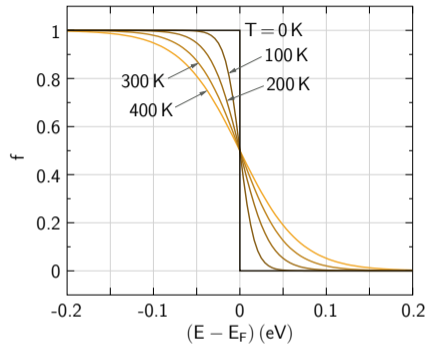
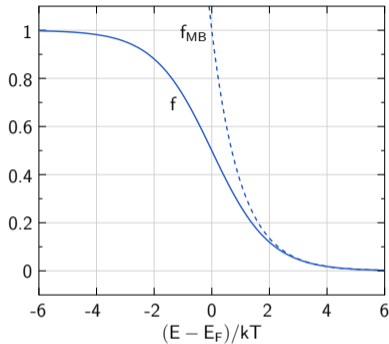
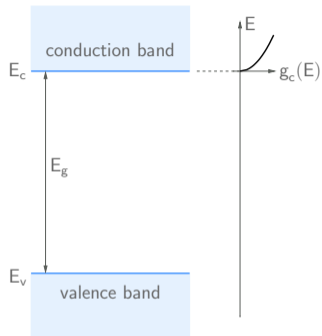


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- * For $E - E_F > 3kT$, $e^{(E-E_F)/kT} > 20$, which is much larger than 1. We then have $f(E) \approx f_{MB}(E) = e^{-(E-E_F)/kT}$, the Maxwell-Boltzmann function.

Electron density (n) in equilibrium

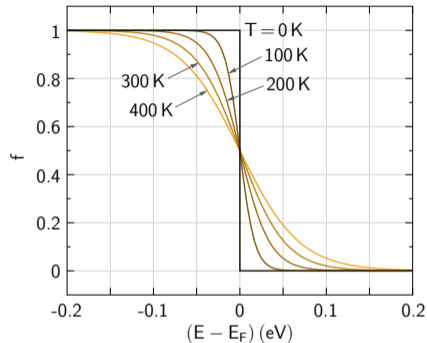
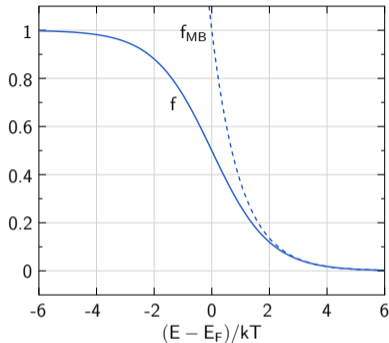
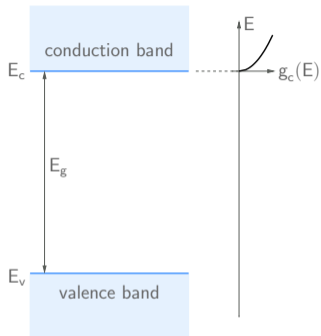


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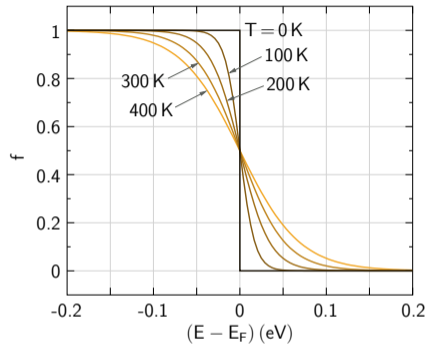
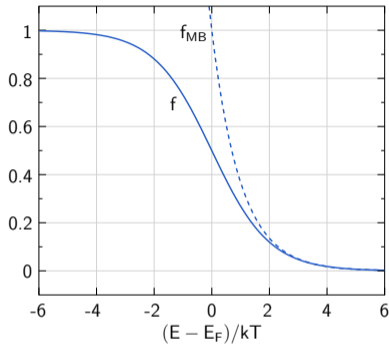
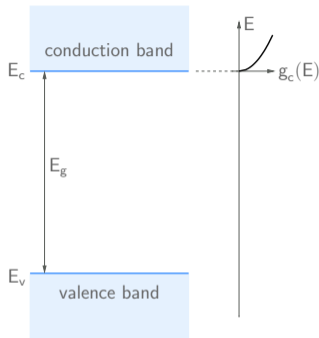
- * Low T : $e^{(E-E_F)/kT}$ varies rapidly with E .
- High T : $e^{(E-E_F)/kT}$ varies slowly with E .

Electron density (n) in equilibrium

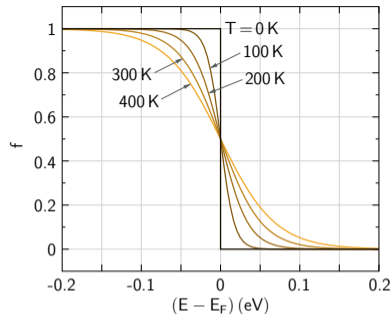
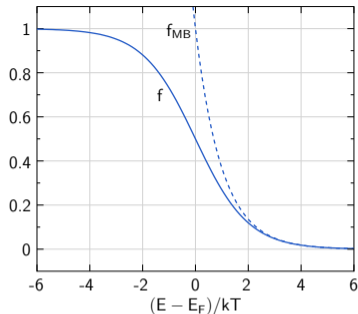
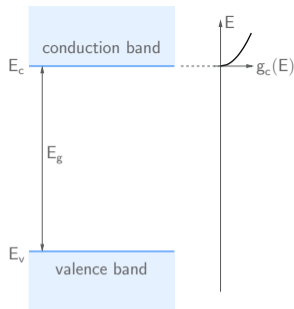


- * Low T : $e^{(E-E_F)/kT}$ varies rapidly with E .
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- $f(E)$ becomes broader as T increases.

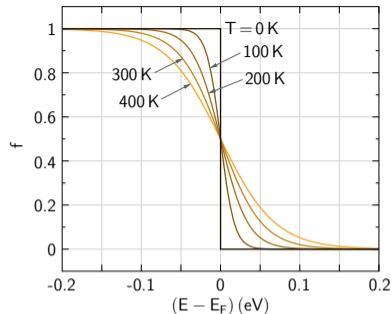
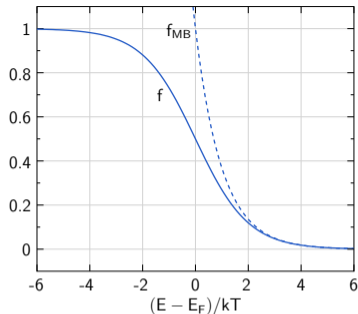
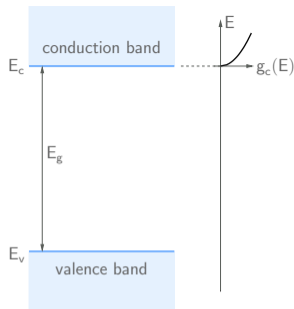
Electron density (n) in equilibrium



- * Low T : $e^{(E-E_F)/kT}$ varies rapidly with E .
High T : $e^{(E-E_F)/kT}$ varies slowly with E .
→ $f(E)$ becomes broader as T increases.
- * Because of the significant variation of $f(E)$ with temperature, we can expect the electron density to have a significant temperature dependence.

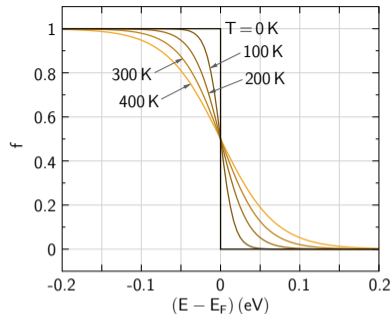
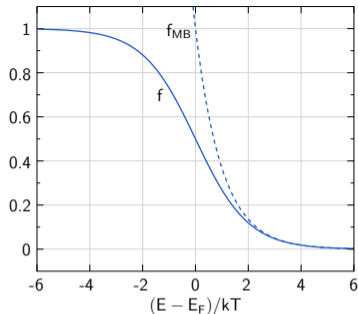
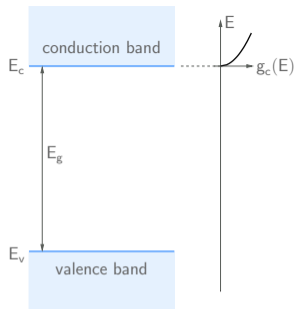


$$n = \int_{E_c}^{\infty} g_c(E) f(E) dE = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \frac{\sqrt{E - E_c}}{1 + e^{(E - E_F)/kT}} dE = \frac{(m_n^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$$



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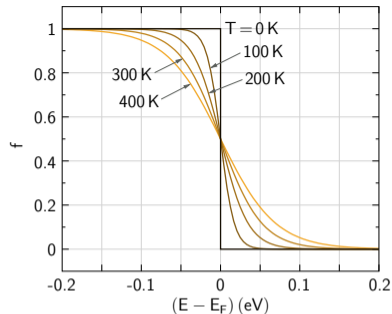
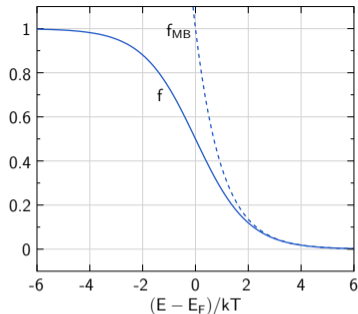
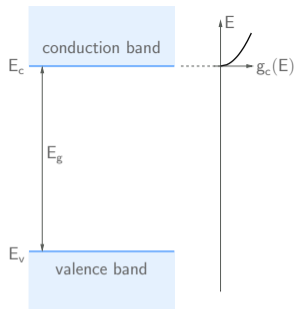
$$\rightarrow n = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c) \text{ with } \eta_c = \frac{E_F - E_c}{kT}.$$



$$n = \int_{E_c}^{\infty} g_c(E) f(E) dE = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \frac{\sqrt{E - E_c}}{1 + e^{(E - E_F)/kT}} dE = \frac{(m_n^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$$

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$$* \mathcal{F}_{1/2}(\eta_c) = \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta, \text{ is called the "Fermi-Dirac integral of order } 1/2."$$

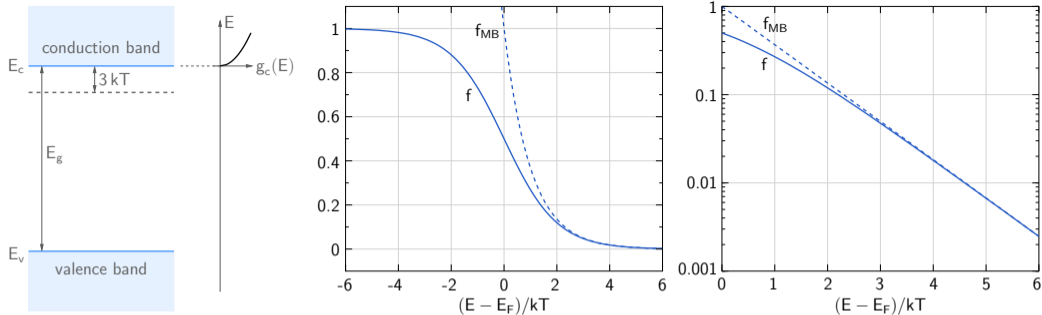


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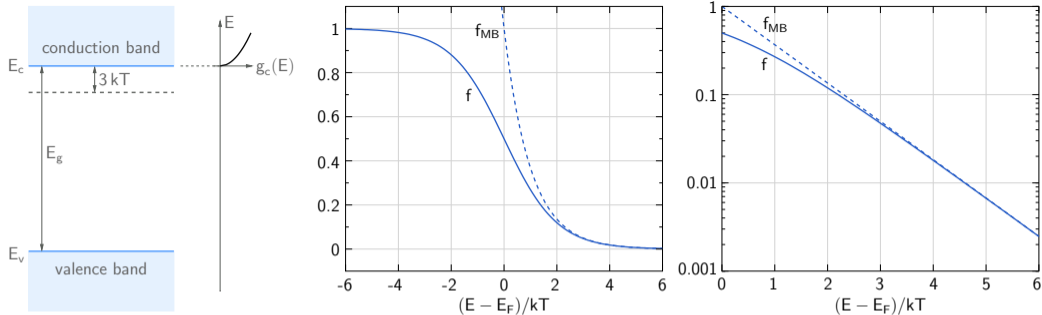
* $\mathcal{F}_{1/2}(\eta_c) = \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_c}} d\eta$, is called the "Fermi-Dirac integral of order 1/2."

* $N_c = 2 \left[\frac{m_n^* kT}{2\pi \hbar^2} \right]^{3/2}$ is called the "effective" density of states for the conduction band.



When the Fermi level is below $E_c - 3kT$, $f(E) \approx f_{MB}(E)$, and

$$\begin{aligned}
 n &= \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} \int_{E_c}^{\infty} \sqrt{E - E_c} \left(e^{-(E - E_F)/kT} \right) dE \\
 &= \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} (kT)^{3/2} \int_0^{\infty} \sqrt{\eta} e^{-\eta} \left(e^{-(E_c - E_F)/kT} \right) d\eta.
 \end{aligned}$$

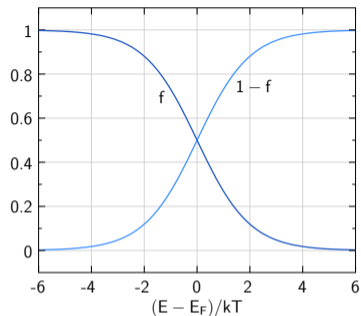
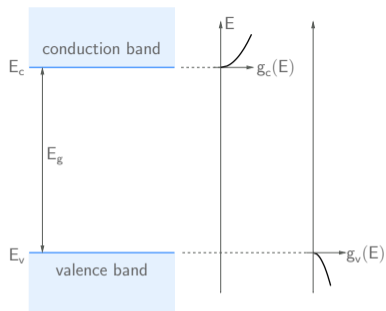


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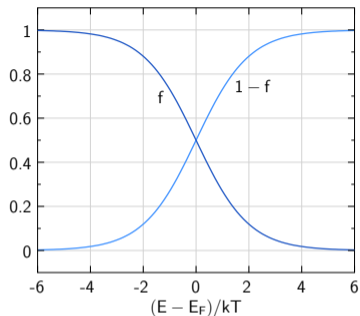
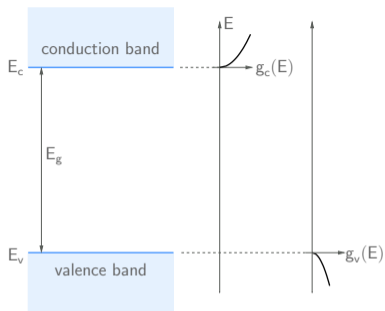
$$\int_0^{\infty} \sqrt{\eta} e^{-\eta} d\eta = \frac{\sqrt{\pi}}{2} \rightarrow n = \frac{(m_n^*)^{3/2} \sqrt{2}}{\pi^2 \hbar^3} (kT)^{3/2} \frac{\sqrt{\pi}}{2} e^{-(E_c - E_F)/kT} = N_c e^{-(E_c - E_F)/kT}.$$

Hole density (ρ) in equilibrium



$$g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}, \quad E < E_v, \quad \rho = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE.$$

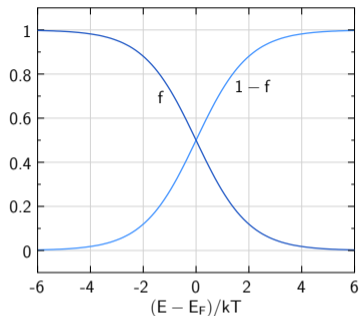
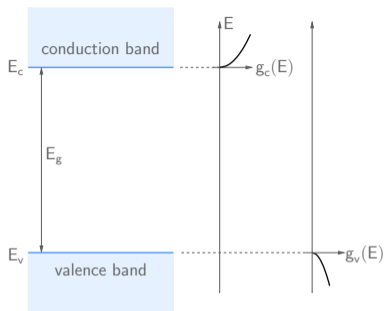
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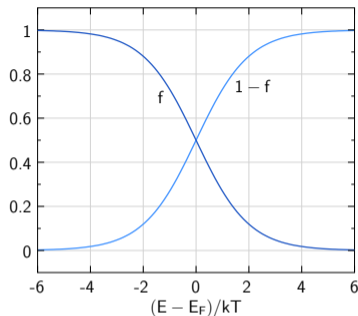
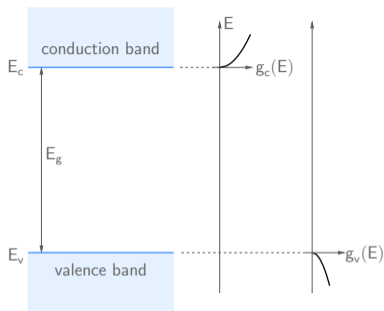
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$$\begin{aligned} \rho &= \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \int_{-\infty}^{E_v} \frac{\sqrt{2(E_v - E)}}{1 + e^{-(E - E_F)/kT}} dE \\ &= \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_v}} d\eta, \quad \text{with } \eta = \frac{E_v - E}{kT} \text{ and } \eta_v = \frac{E_v - E_F}{kT} \end{aligned}$$

Hole density (ρ) in equilibrium



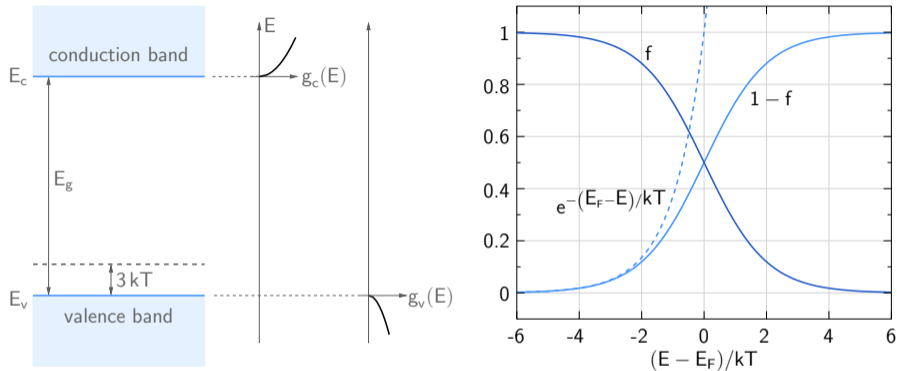
$$g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}, \quad E < E_v, \quad \rho = \int_{-\infty}^{E_v} g_v(E) (1 - f(E)) dE.$$

$$\rho = \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \int_{-\infty}^{E_v} \frac{\sqrt{2(E_v - E)}}{1 + e^{-(E - E_F)/kT}} dE$$

$$= \frac{(m_p^*)^{3/2}}{\pi^2 \hbar^3} \sqrt{2} (kT)^{3/2} \int_0^{\infty} \frac{\eta^{1/2}}{1 + e^{\eta - \eta_v}} d\eta, \quad \text{with } \eta = \frac{E_v - E}{kT} \text{ and } \eta_v = \frac{E_v - E_F}{kT}$$

$$= N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \text{where } N_v = 2 \left[\frac{m_p^* kT}{2\pi \hbar^2} \right]^{3/2} \text{ is the effective density of states for the valence band.}$$

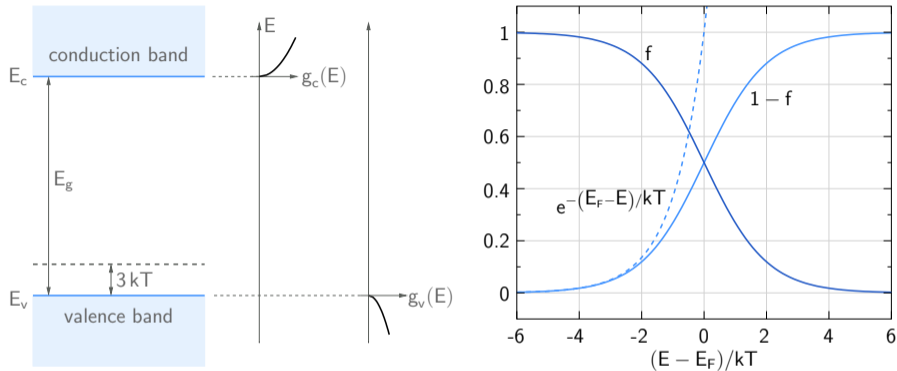
Hole density (ρ) in equilibrium



When $E_F > E_v + 3kT$, $1 - f(E)$ can be approximated using the Maxwell-Boltzmann function.

$$1 - f(E) \approx e^{-(E_F - E)/kT} \rightarrow \rho = N_v e^{-(E_F - E_v)/kT}.$$

Hole density (ρ) in equilibrium



When $E_F > E_v + 3kT$, $1 - f(E)$ can be approximated using the Maxwell-Boltzmann function.

$$1 - f(E) \approx e^{-(E_F - E)/kT} \rightarrow p = N_v e^{-(E_F - E_v)/kT}.$$





$$E_F > E_c - 3kT$$

(degenerate semiconductor)

$$n = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = - \left(\frac{E_c - E_F}{kT} \right)$$

$$p = N_v e^{-(E_F - E_v)/kT}$$

$$E_v + 3kT < E_F < E_c - 3kT$$

(non-degenerate semiconductor)

$$n = N_c e^{-(E_c - E_F)/kT}$$

$$p = N_v e^{-(E_F - E_v)/kT}$$

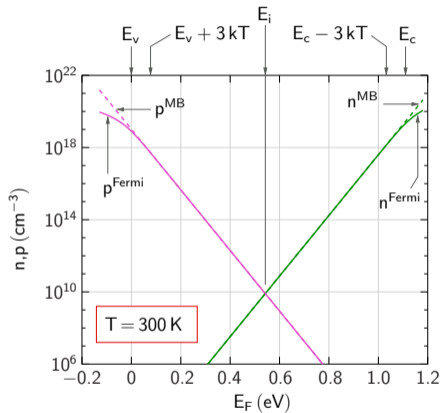


$$E_F < E_v + 3kT$$

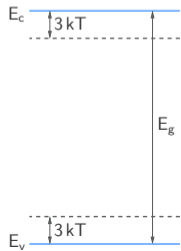
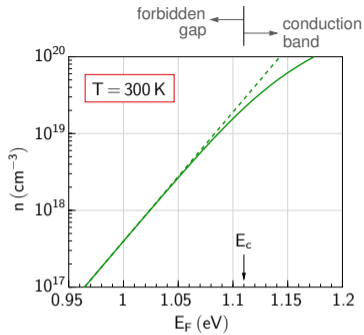
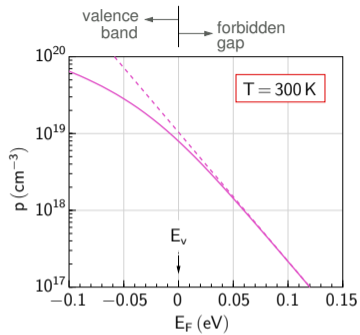
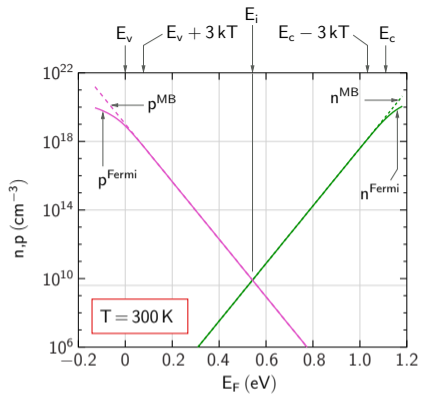
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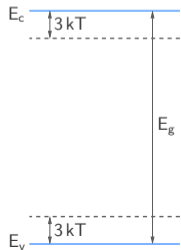
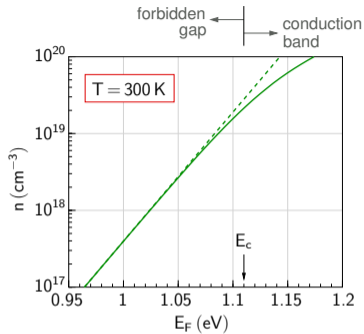
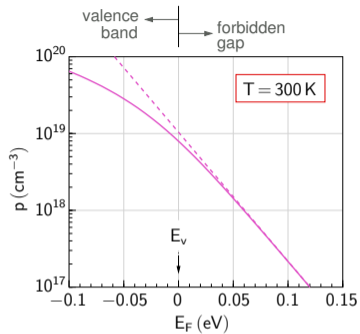
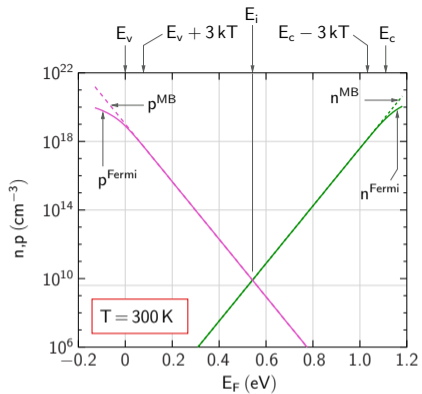
$$n = N_c e^{-(E_c - E_F)/kT}$$

$$p = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = - \left(\frac{E_F - E_v}{kT} \right)$$



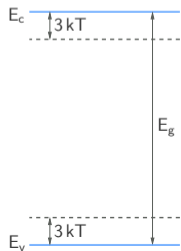
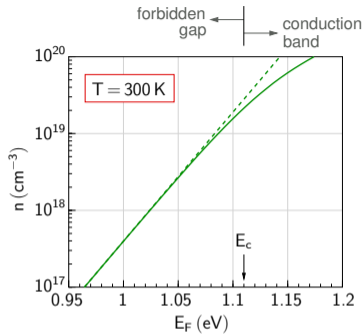
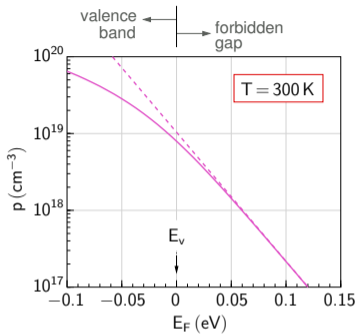
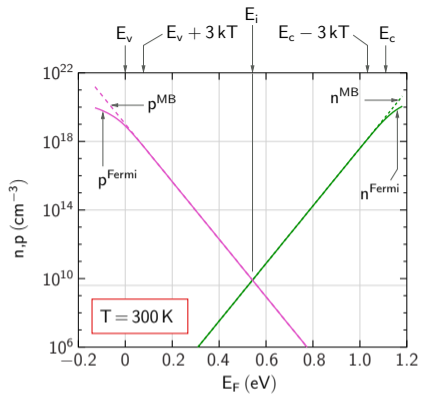
Electron and hole densities in silicon





$$* n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = - \left(\frac{E_c - E_F}{kT} \right)$$

$$* n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$$

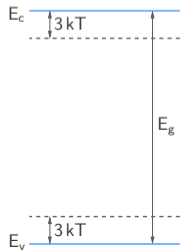
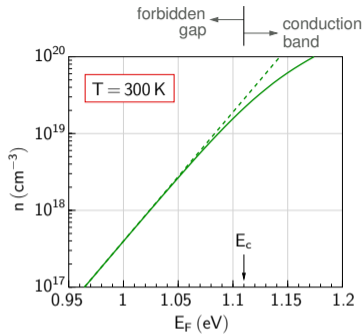
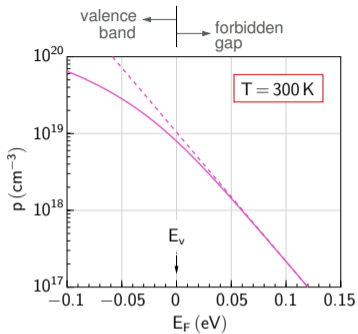
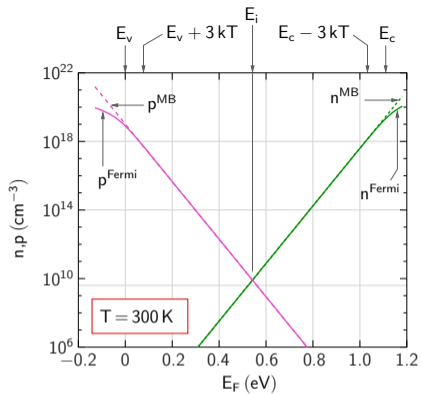


$$* n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = - \left(\frac{E_c - E_F}{kT} \right)$$

$$* p^{\text{Fermi}} = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = - \left(\frac{E_F - E_v}{kT} \right)$$

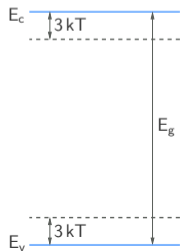
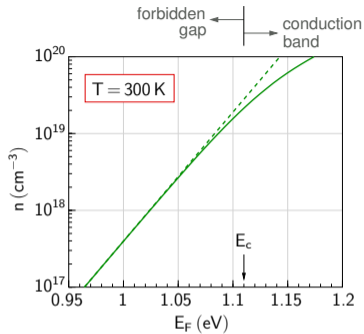
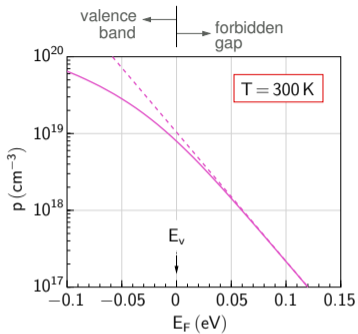
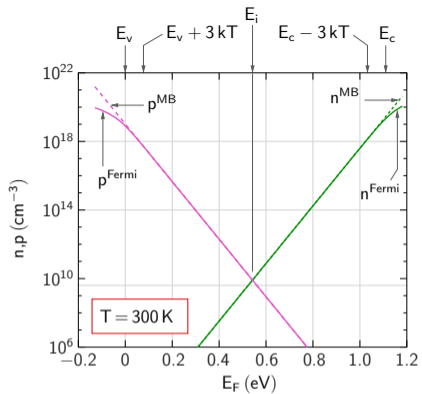
$$* n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$$

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- * $n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = -\left(\frac{E_c - E_F}{kT}\right)$
- * $p^{\text{Fermi}} = N_v \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_v), \quad \eta_v = -\left(\frac{E_F - E_v}{kT}\right)$
- * For $E_F < (E_c - 3kT), n^{\text{MB}} \approx n^{\text{Fermi}}$

- * $n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$
- * $p^{\text{MB}} = N_v e^{-(E_F - E_v)/kT}$



$$* n^{\text{Fermi}} = N_c \frac{2}{\sqrt{\pi}} \mathcal{F}_{1/2}(\eta_c), \quad \eta_c = - \left(\frac{E_c - E_F}{kT} \right)$$

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$$* \text{For } E_F < (E_c - 3kT), \quad n^{\text{MB}} \approx n^{\text{Fermi}}$$

$$* \text{For } E_F > (E_v + 3kT), \quad p^{\text{MB}} \approx p^{\text{Fermi}}$$

$$* n^{\text{MB}} = N_c e^{-(E_c - E_F)/kT}$$

$$* p^{\text{MB}} = N_v e^{-(E_F - E_v)/kT}$$

For silicon at $T = 300\text{ K}$ and in equilibrium (with $N_c = 2.8 \times 10^{19}\text{ cm}^{-3}$, $N_v = 1.04 \times 10^{19}\text{ cm}^{-3}$, $E_g = 1.12\text{ eV}$),

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- (a) Find E_F for which n and p are equal. This Fermi level is called E_i , the “intrinsic” Fermi level.

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- (a) Find E_F for which n and p are equal. This Fermi level is called E_i , the “intrinsic” Fermi level.
- (b) Obtain expressions for n and p in terms of $(E_i - E_F)$ (instead of $(E_c - E_F)$ and $(E_F - E_v)$). Assume non-degenerate conditions.

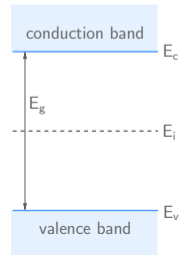
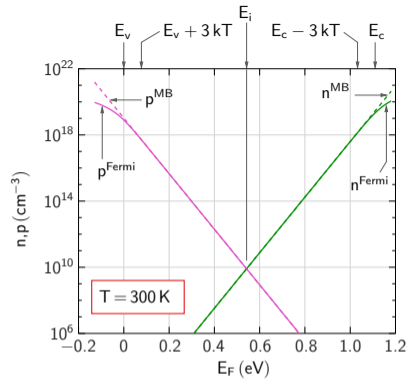
For silicon at $T = 300\text{ K}$ and in equilibrium (with $N_c = 2.8 \times 10^{19}\text{ cm}^{-3}$, $N_v = 1.04 \times 10^{19}\text{ cm}^{-3}$, $E_g = 1.12\text{ eV}$),

- Find E_F for which n and p are equal. This Fermi level is called E_i , the “intrinsic” Fermi level.
- Obtain expressions for n and p in terms of $(E_i - E_F)$ (instead of $(E_c - E_F)$ and $(E_F - E_v)$). Assume non-degenerate conditions.
- Plot $g_c(E) f(E)$ and $g_v(E) [1 - f(E)]$ versus E for
 - $E_F = E_i + 20\text{ meV}$,
 - $E_F = E_i + 10\text{ meV}$,
 - $E_F = E_i$,
 - $E_F = E_i - 10\text{ meV}$,
 - $E_F = E_i - 20\text{ meV}$.

The condition $n = p$ is satisfied when E_F is about $(E_v + E_c)/2$.

→ We can use MB statistics, i.e.,

$$N_c e^{-(E_c - E_F)/kT} = N_v e^{-(E_F - E_v)/kT}$$

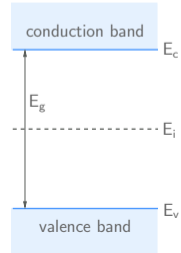
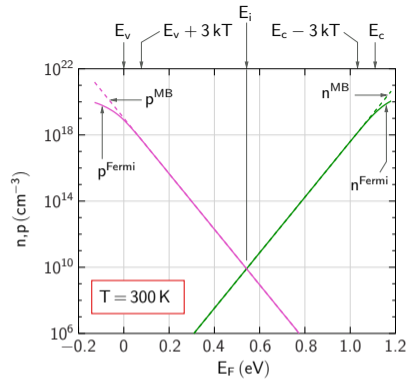


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$$\rightarrow -E_c + E_F + E_F - E_v = kT \log \frac{N_v}{N_c}.$$



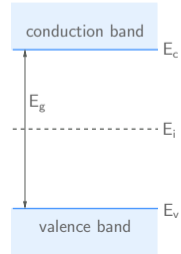
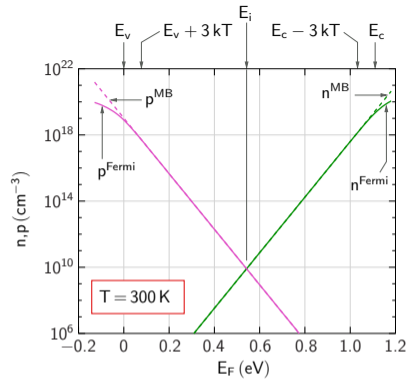
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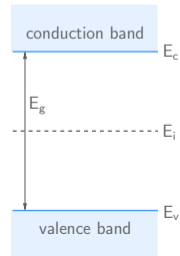
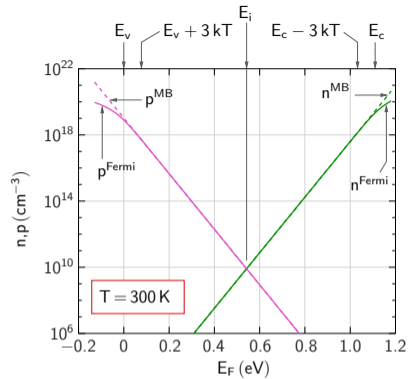
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$$\rightarrow E_F = \frac{1}{2} (E_c + E_v) + \frac{kT}{2} \log \frac{N_v}{N_c}.$$

$$N_v/N_c = (m_p^*/m_n^*)^{3/2} \rightarrow E_F \equiv E_i = \frac{1}{2} (E_c + E_v) + \frac{3}{4} kT \log \frac{m_p^*}{m_n^*}.$$



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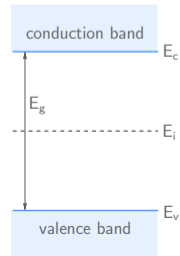
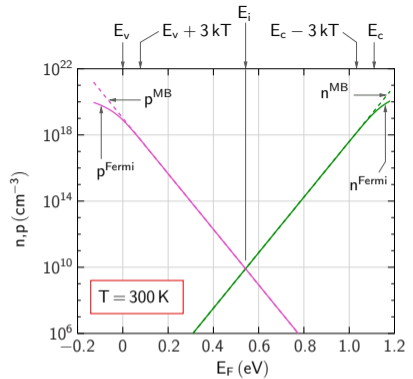
$$N_C e^{-(E_C - E_F)/kT} = N_V e^{-(E_F - E_V)/kT}$$

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- * The second term in the above equation is about -7.3 meV, i.e., the intrinsic Fermi level E_i is located 7.3 meV below the centre of the band gap.



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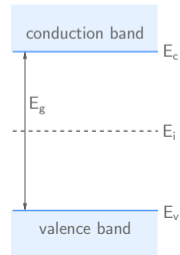
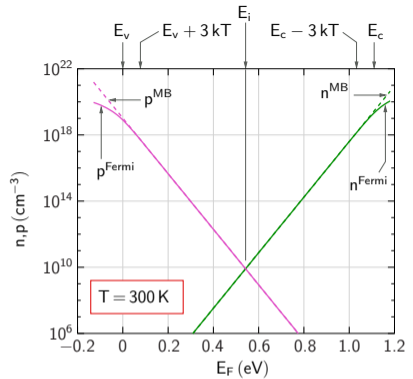
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- * The second term in the above equation is about -7.3 meV, i.e., the intrinsic Fermi level E_i is located 7.3 meV below the centre of the band gap.
- * If N_C and N_V were equal, E_i would be exactly at the centre of the band gap.



When $E_F = E_i$, we have $n = p \equiv n_i$, the “intrinsic carrier concentration.”

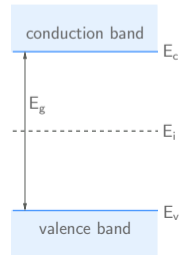
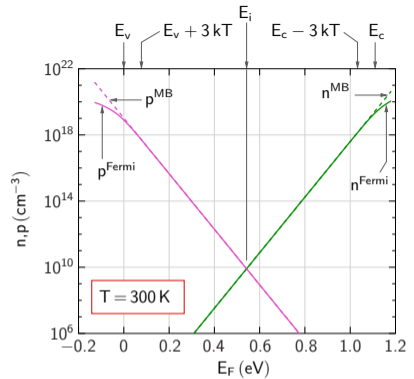
The actual electron concentration (for a given Fermi level E_F) can be written in terms of n_i as follows.

$$n = N_c e^{-(E_c - E_F)/kT}, \quad n_i = N_c e^{-(E_c - E_i)/kT}.$$

$$\rightarrow \frac{n}{n_i} = e^{(E_F - E_i)/kT} \rightarrow n = n_i e^{(E_F - E_i)/kT}.$$

Similarly, for the hole concentration p , we obtain

$$p = n_i e^{(E_i - E_F)/kT}.$$



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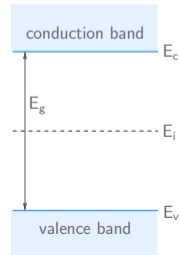
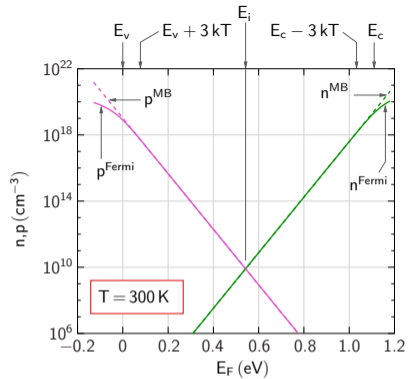
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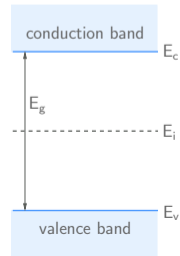
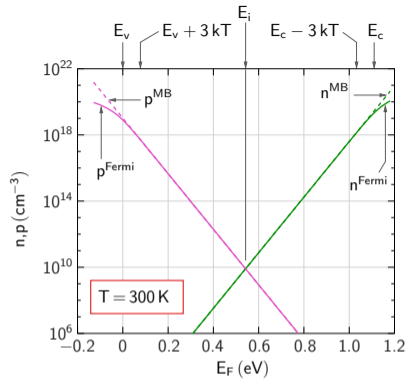
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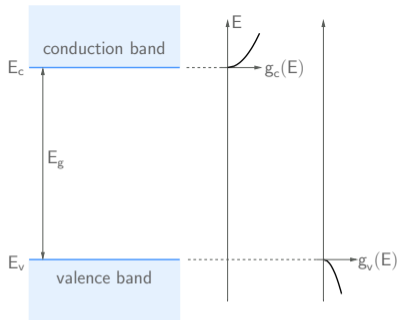
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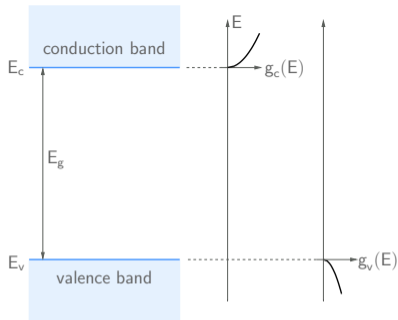
$$* g_c(E) = \frac{(m_n^*)^{3/2} \sqrt{2(E - E_c)}}{\pi^2 \hbar^3}$$

$$* g_v(E) = \frac{(m_p^*)^{3/2} \sqrt{2(E_v - E)}}{\pi^2 \hbar^3}$$

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$$* n = \int_{E_c}^{\infty} g_c(E) f(E) dE$$

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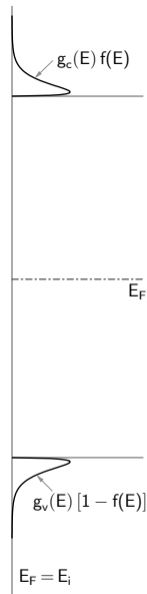
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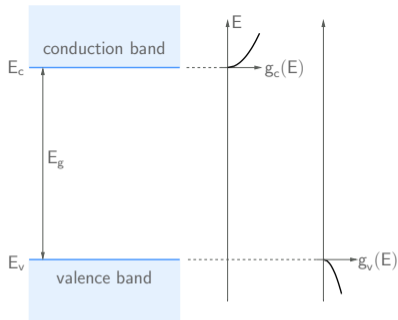
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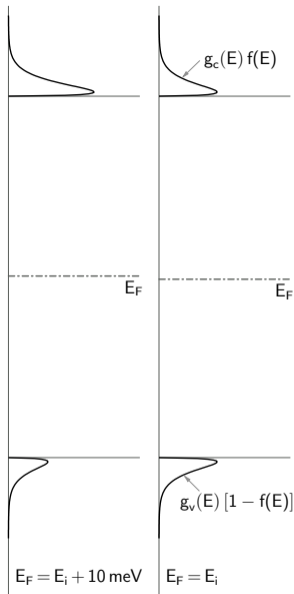
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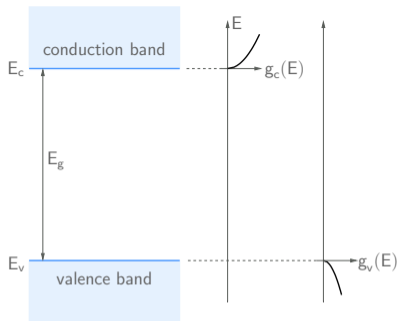
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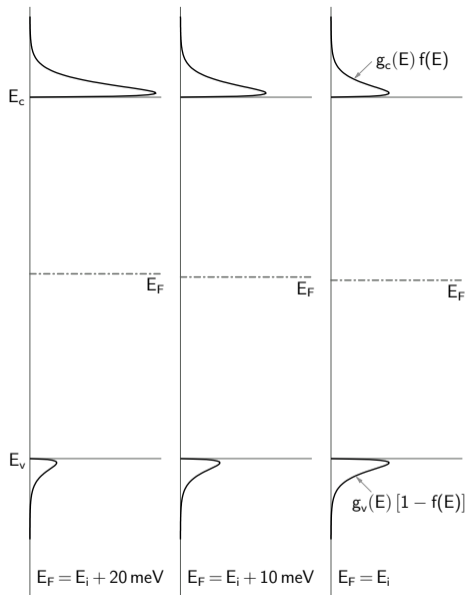
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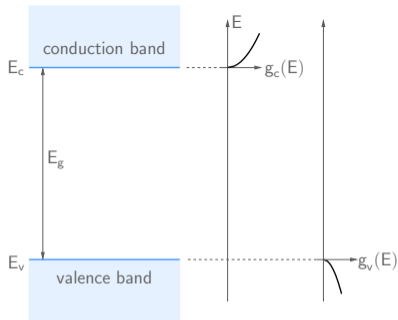
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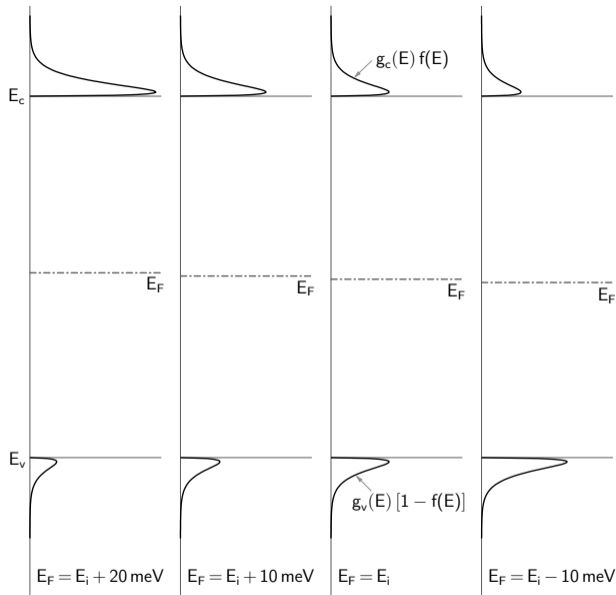
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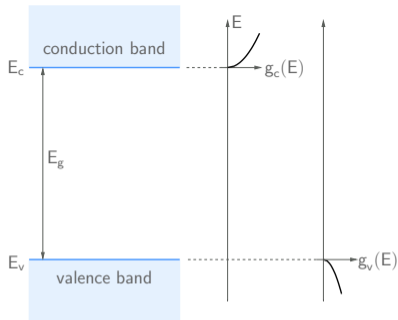
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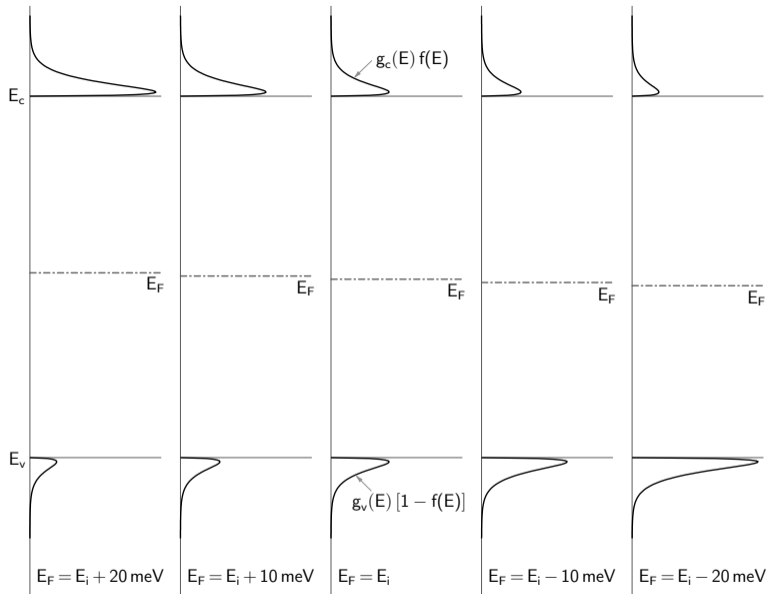
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Temperature dependence of n_i

$$n = N_c e^{-(E_c - E_F)/kT}, \quad p = N_v e^{-(E_F - E_v)/kT}.$$

When $E_F = E_i$, $n = p = n_i$, i.e.,

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$$\begin{aligned} \rightarrow n_i &= \sqrt{N_c N_v} e^{-E_g/2kT} \\ &= 2 (m_n^* m_p^*)^{3/4} \left(\frac{kT}{2\pi\hbar^2} \right)^{3/2} e^{-E_g/2kT} \\ &\equiv K T^{3/2} e^{-E_g/2kT} \end{aligned}$$

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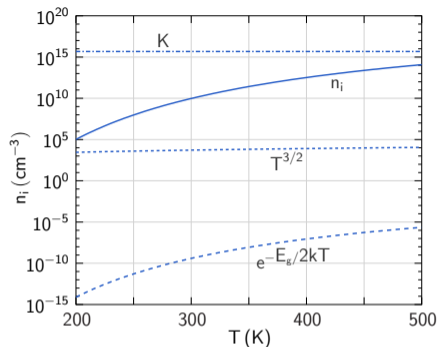
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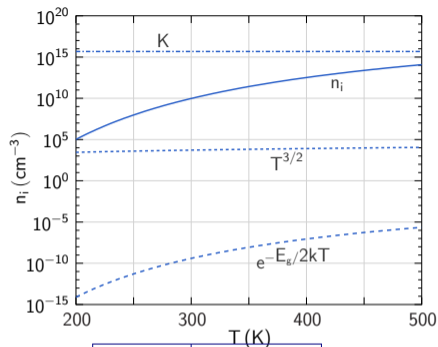
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T ($^{\circ}\text{C}$)	n_i (cm^{-3})
25	8.1×10^9
35	1.7×10^{10}
45	3.5×10^{10}
55	6.9×10^{10}
65	1.3×10^{11}
75	2.3×10^{11}

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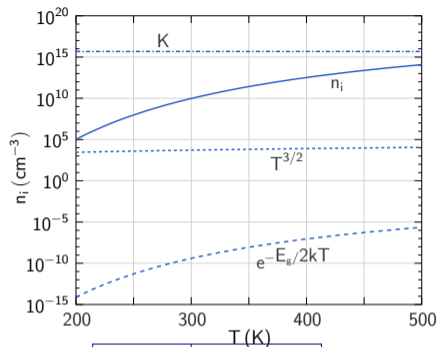
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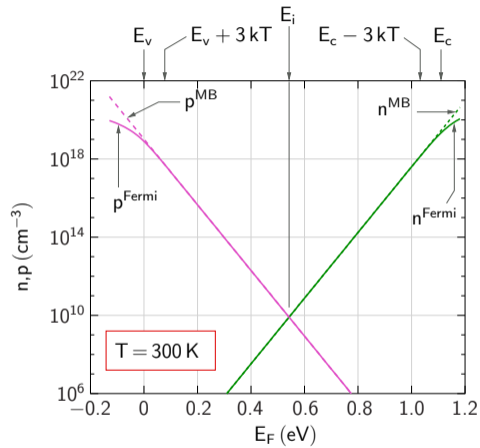
$$\begin{aligned} \rightarrow n_i &= \sqrt{N_c N_v} e^{-E_g/2kT} \\ &= 2(m_n^* m_p^*)^{3/4} \left(\frac{kT}{2\pi\hbar^2} \right)^{3/2} e^{-E_g/2kT} \\ &\equiv K T^{3/2} e^{-E_g/2kT} \end{aligned}$$

For silicon, near room temperature, n_i nearly doubles with every 10°C rise in temperature.



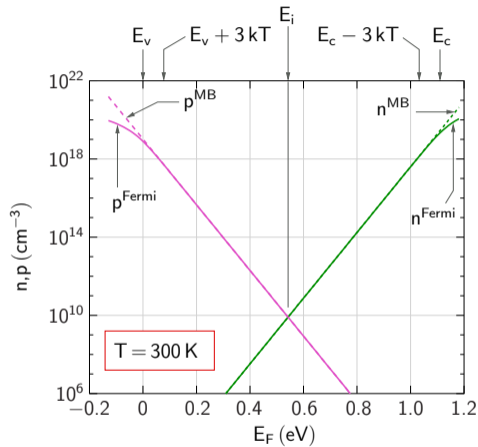
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How to obtain E_F



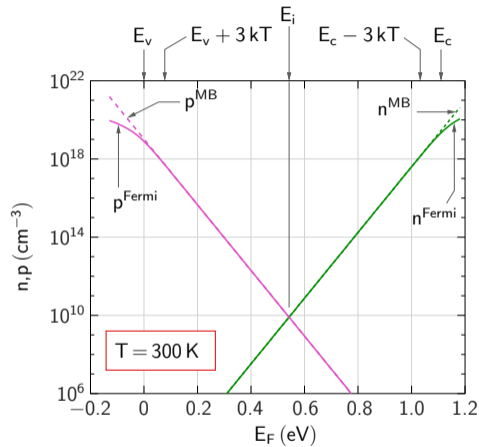
How to obtain E_F

- * So far, we have assumed a certain E_F (with respect to E_c and E_v) and obtained n and p .



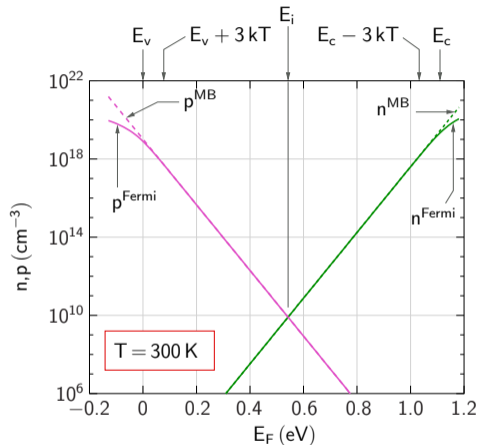
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- * In practice, we only have information such as N_C , N_V , E_g , T , and doping densities (N_a and N_d).

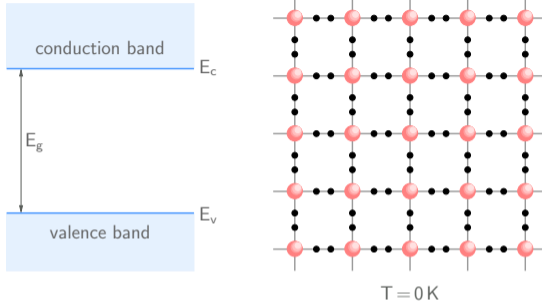


How to obtain E_F

- * So far, we have assumed a certain E_F (with respect to E_C and E_V) and obtained n and p .
- * In practice, we only have information such as N_C , N_V , E_g , T , and doping densities (N_a and N_d).
- * We now want to consider the reverse problem of finding E_F (and n , p), given the above data.

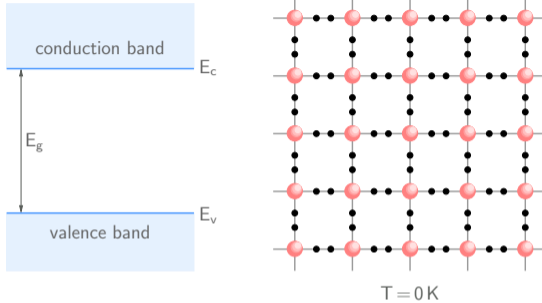


Charge considerations in equilibrium: intrinsic semiconductor



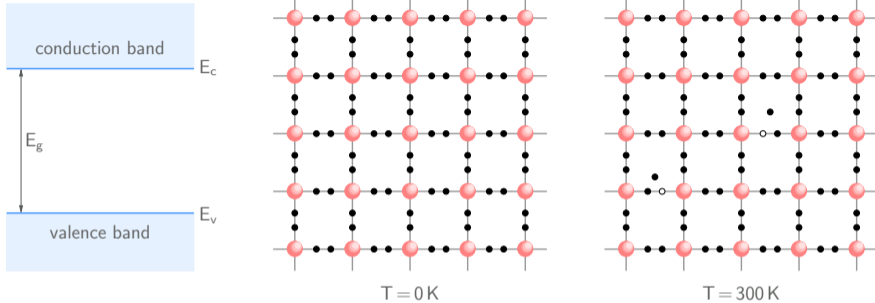
- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.

Charge considerations in equilibrium: intrinsic semiconductor



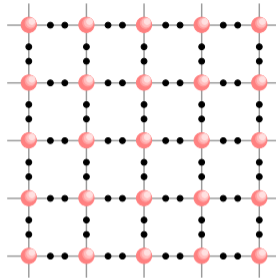
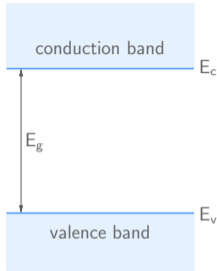
- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
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Charge considerations in equilibrium: intrinsic semiconductor

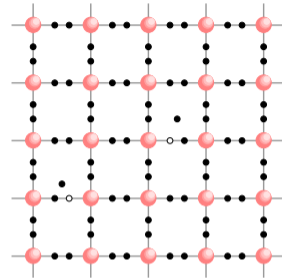


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Charge considerations in equilibrium: intrinsic semiconductor



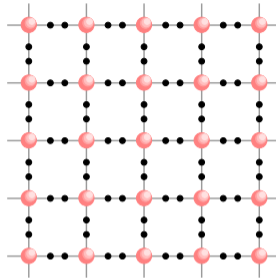
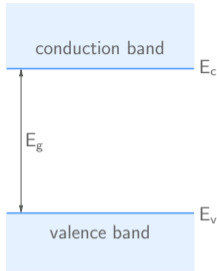
T = 0 K



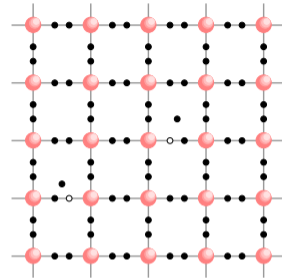
T = 300 K

- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
- * As temperature increases, some of the valence electrons become free, i.e., they enter the conduction band, leaving behind positively charged holes in the valence band.
- * The number of electrons in the conduction band is equal to the number of holes in the valence band.

Charge considerations in equilibrium: intrinsic semiconductor



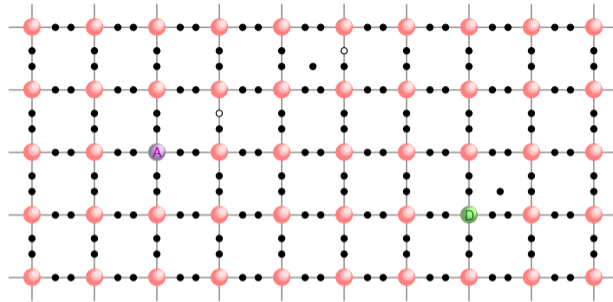
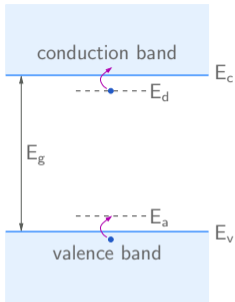
T = 0 K



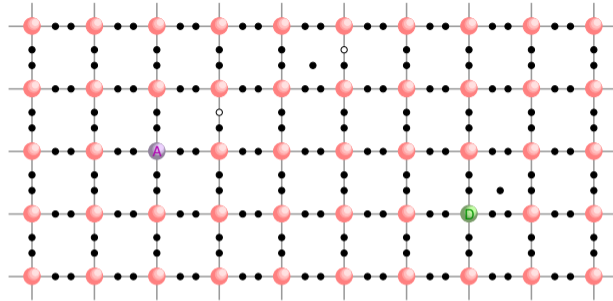
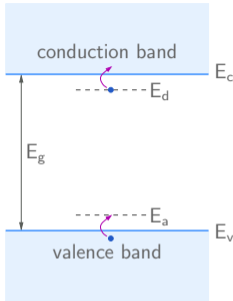
T = 300 K

- * At 0 K, the positive charge due to the atomic cores balances the negative charge due to valence electrons.
- * As temperature increases, some of the valence electrons become free, i.e., they enter the conduction band, leaving behind positively charged holes in the valence band.
- * The number of electrons in the conduction band is equal to the number of holes in the valence band.
- * Also, their densities must be equal since the electrostatic potential is constant (no electric field) $\rightarrow n = p$.

Charge considerations in equilibrium: doped semiconductor

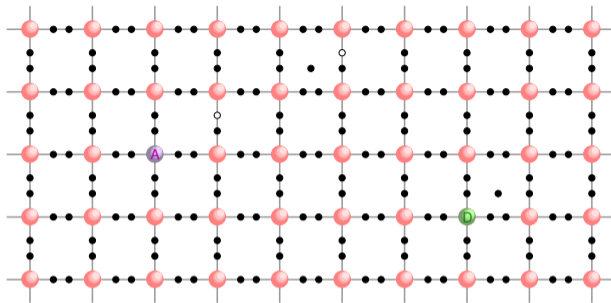
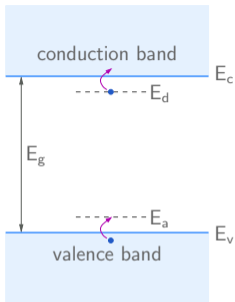


Charge considerations in equilibrium: doped semiconductor



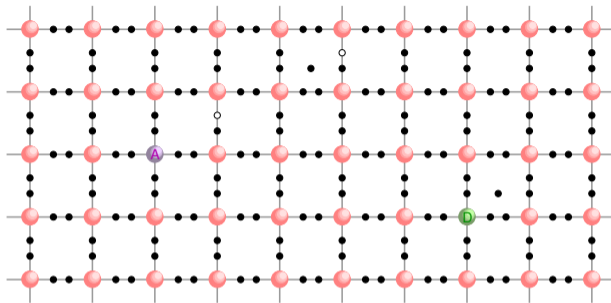
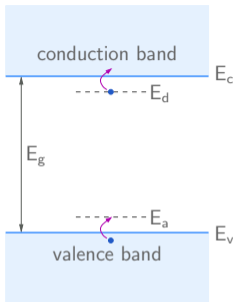
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Charge considerations in equilibrium: doped semiconductor



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 - electrons in the conduction band (density n)

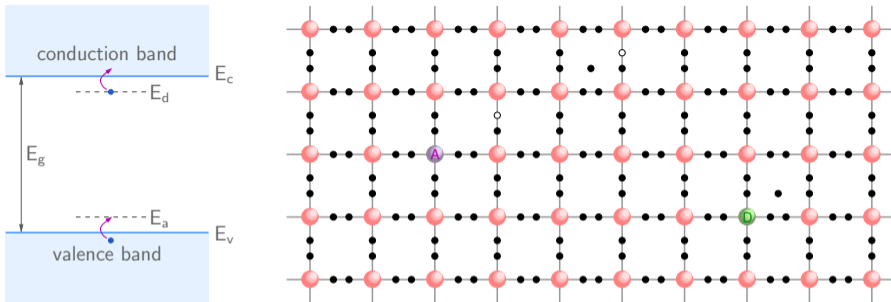
Charge considerations in equilibrium: doped semiconductor



* When there are donor or acceptor atoms in the lattice, we have the following charged species.

- electrons in the conduction band (density n)
- holes in the valence band (density p)

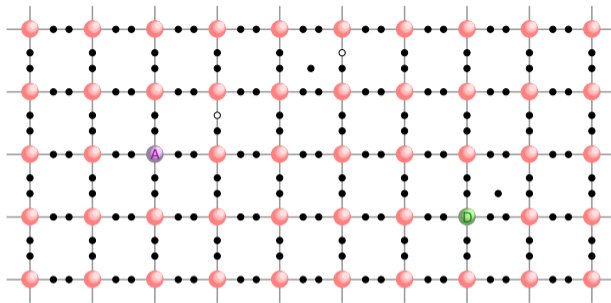
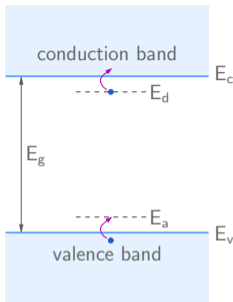
Charge considerations in equilibrium: doped semiconductor



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- holes in the valence band (density p)
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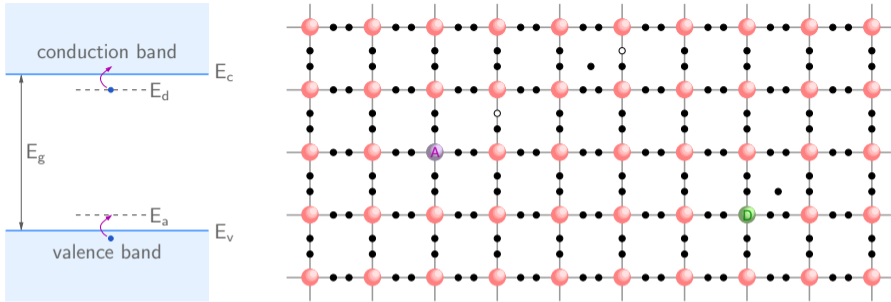
Charge considerations in equilibrium: doped semiconductor



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Charge considerations in equilibrium: doped semiconductor



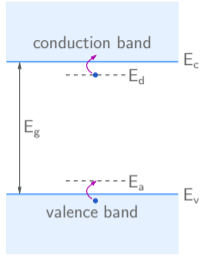
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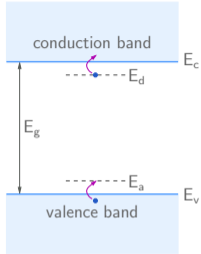
* If the doping densities (N_a or N_d or both) are uniform in space, charge neutrality in equilibrium requires

$$-qn + qp + qN_d^+ - qN_a^- = 0 \rightarrow n + N_a^- = p + N_d^+.$$

Charge considerations in equilibrium

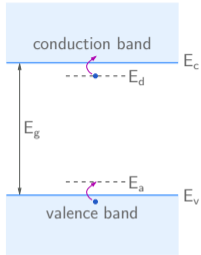


Charge considerations in equilibrium



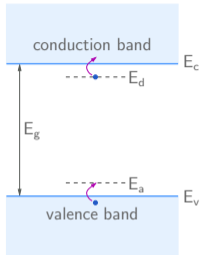
- * Let the donor density be N_d . Some of the donor atoms donate their electrons and acquire a net positive charge; the others remain neutral. $\rightarrow N_d = N_d^+ + N_d^0$.

Charge considerations in equilibrium



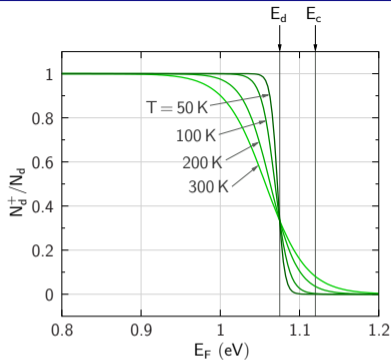
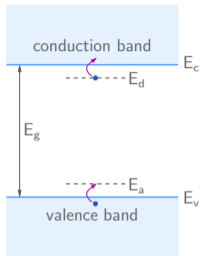
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Charge considerations in equilibrium



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- * Similarly, $N_a = N_a^- + N_a^0$.
- * The ratios N_d^+/N_d and N_a^-/N_a are given by $\frac{N_d^+}{N_d} = \frac{1}{1 + 2 e^{(E_F - E_d)/kT}}$, $\frac{N_a^-}{N_a} = \frac{1}{1 + 4 e^{(E_a - E_F)/kT}}$.

Charge considerations in equilibrium

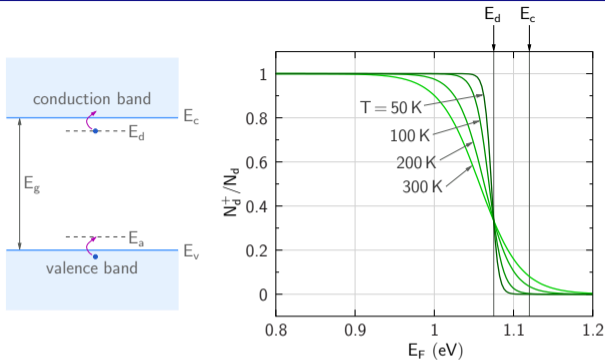


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Charge considerations in equilibrium



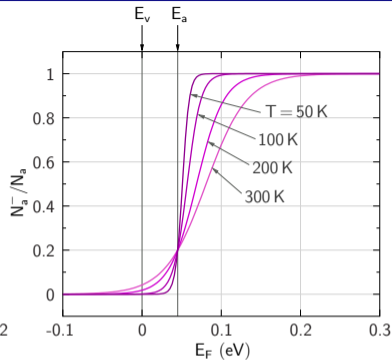
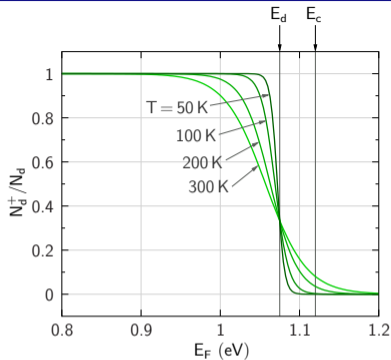
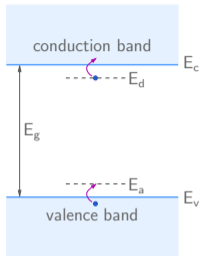
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Charge considerations in equilibrium



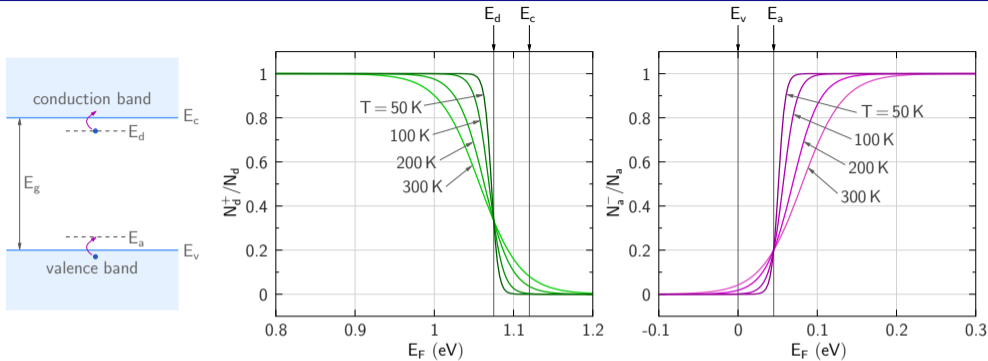
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Charge considerations in equilibrium



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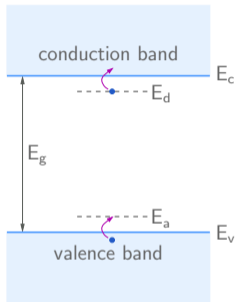
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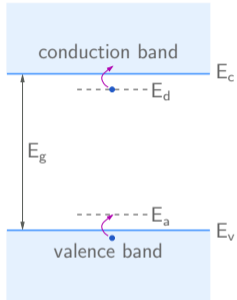
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Calculation of n and p in equilibrium

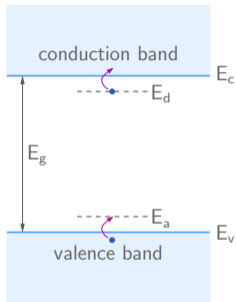


Calculation of n and p in equilibrium



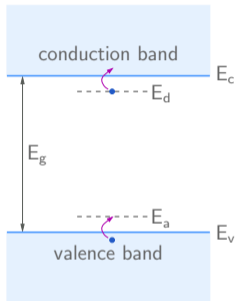
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Calculation of n and p in equilibrium



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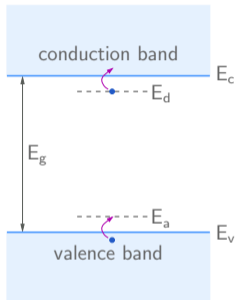
$$* N_c e^{-(E_c - E_F)/kT} + \frac{N_a}{1 + 4 e^{(E_a - E_F)/kT}} = N_v e^{-(E_F - E_v)/kT} + \frac{N_d}{1 + 2 e^{(E_F - E_d)/kT}}$$



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$$* \text{We can take } E_v \text{ as a reference} \rightarrow E_v = 0, E_c = E_g.$$

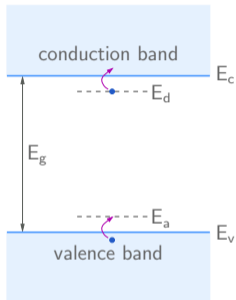


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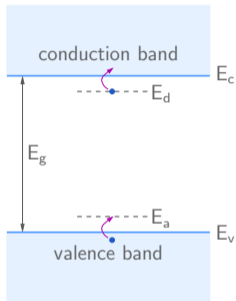
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* Note that E_g depends on the temperature. For silicon,

$$E_g(T) = E_g(0) - \alpha T^2 / (\beta + T),$$

with $E_g(0) = 1.17$ eV, $\alpha = 4.73 \times 10^{-4}$ eV/K, and $\beta = 636$ K.



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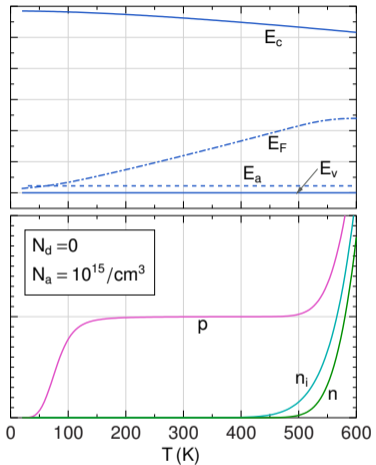
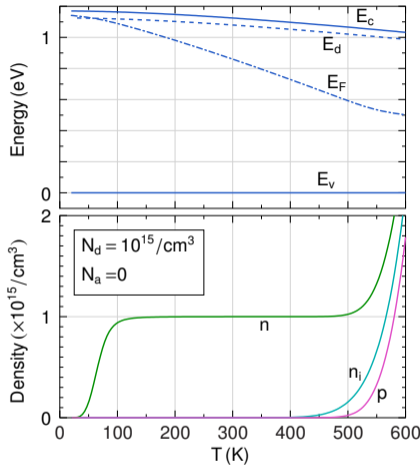
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* Let us look at the results obtained for a few representative values of N_d and N_a , with $E_c - E_d = 45$ meV, $E_a - E_v = 45$ meV.

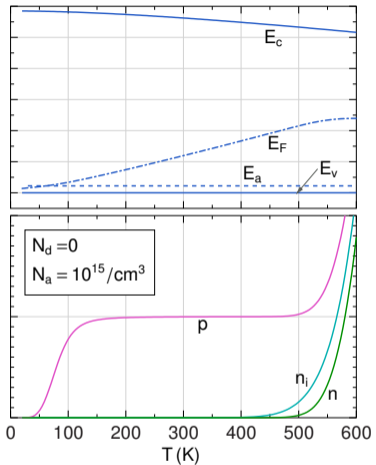
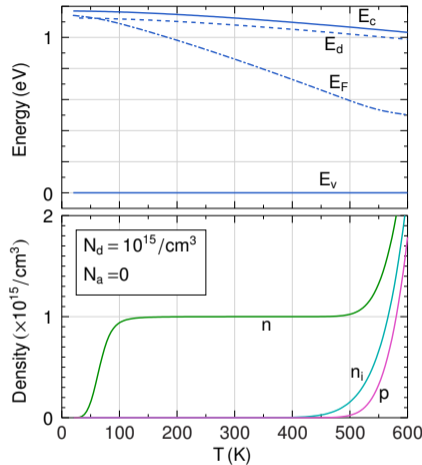
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K),
 $n \approx N_d$, and $p \ll n$.



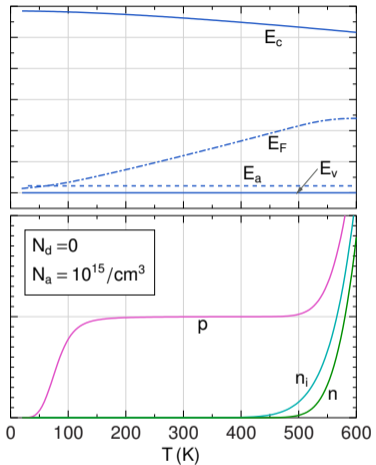
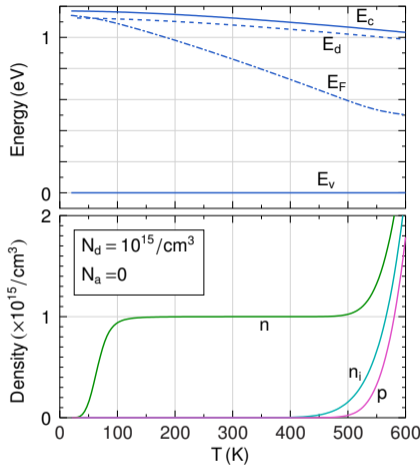
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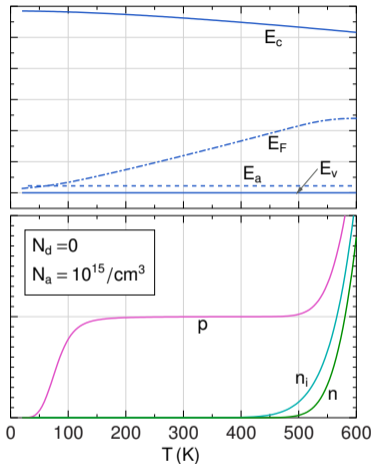
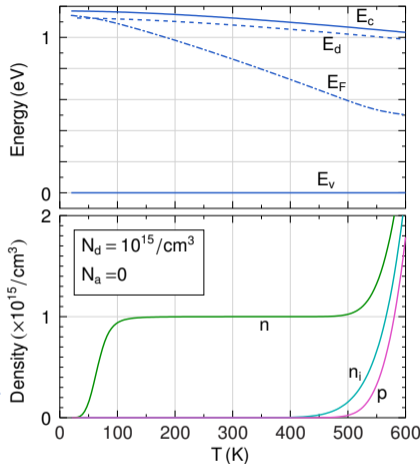
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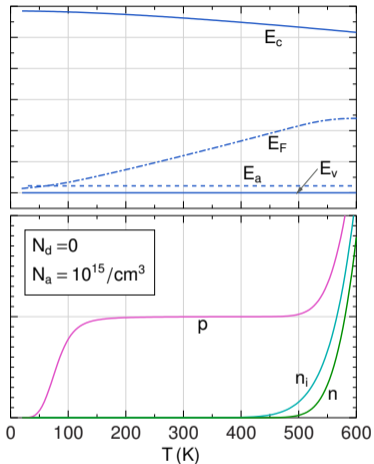
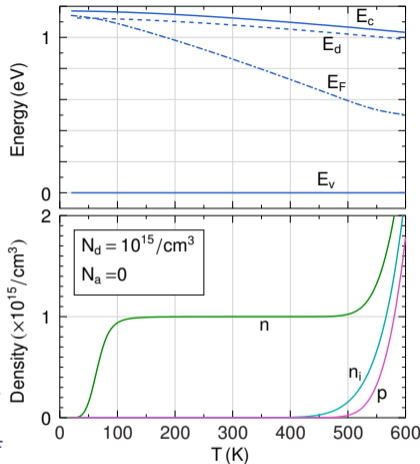
n and p in equilibrium

- * With $N_d = 10^{15} \text{ cm}^{-3}$ and $N_a = 0$,
 - At room temperature (300 K), $n \approx N_d$, and $p \ll n$.
 - Since $N_d^+ + p = n$, we have $N_d^+ \approx N_d$, i.e., complete ionisation of the donor atoms.
- * With $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$,
 - At room temperature (300 K), $p \approx N_a$, and $n \ll p$.
 - Since $N_a^- + n = p$, we have $N_a^- \approx N_a$, i.e., complete ionisation of the acceptor atoms.



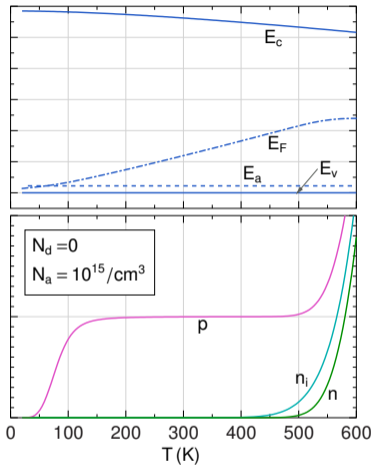
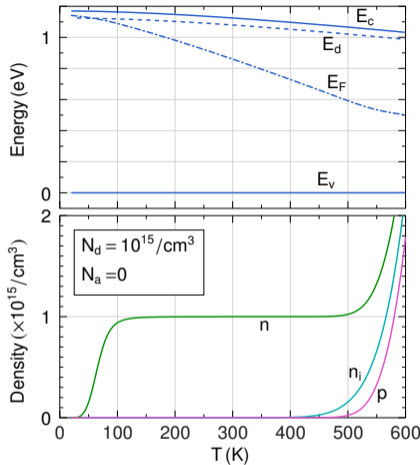
n and p in equilibrium

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 - At room temperature (300 K), $n \approx N_d$, and $p \ll n$.
 - Since $N_d^+ + p = n$, we have $N_d^+ \approx N_d$, i.e., complete ionisation of the donor atoms.
- * With $N_a = 10^{15} \text{ cm}^{-3}$ and $N_d = 0$,
 - At room temperature (300 K), $p \approx N_a$, and $n \ll p$.
 - Since $N_a^- + n = p$, we have $N_a^- \approx N_a$, i.e., complete ionisation of the acceptor atoms.
- * In fact, the condition of complete ionisation is valid over a wide range of temperatures, called the “extrinsic” temperature region.



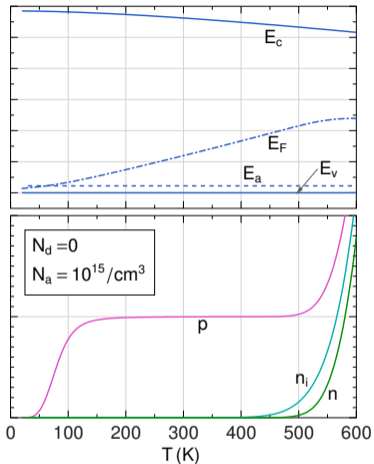
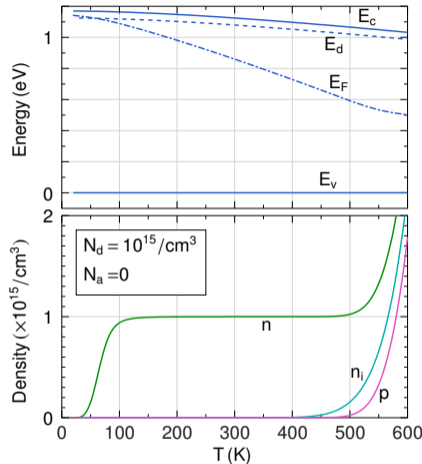
n and p in equilibrium

- * Note that one of the carrier densities is much larger than the other (in the extrinsic region). The more abundant carrier is called the “majority carrier,” and the other carrier is called the “minority carrier.”



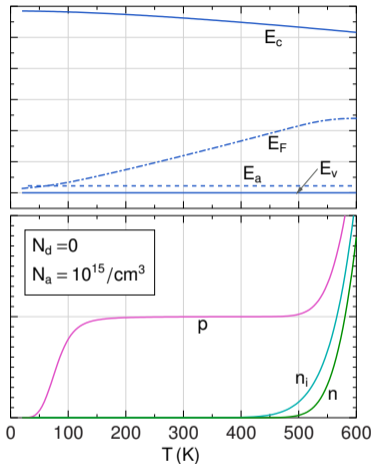
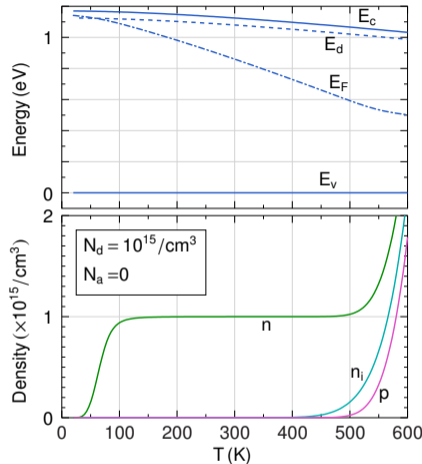
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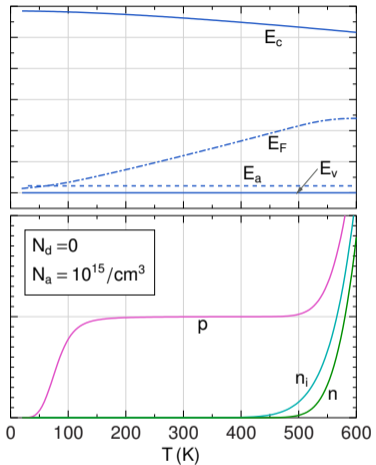
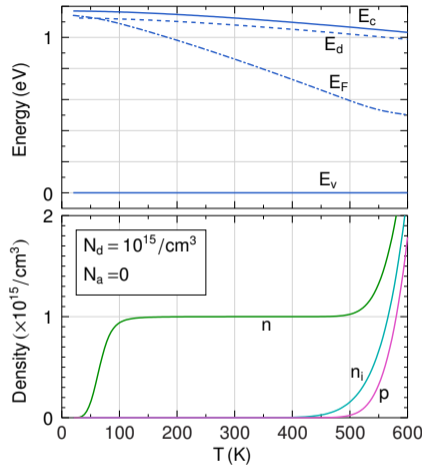
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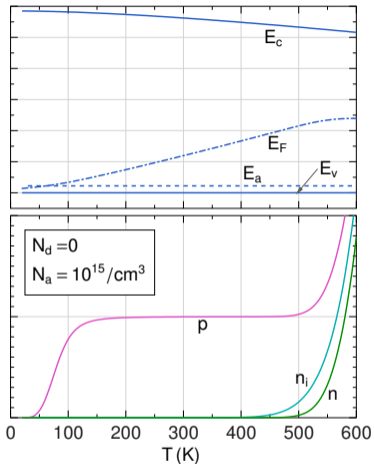
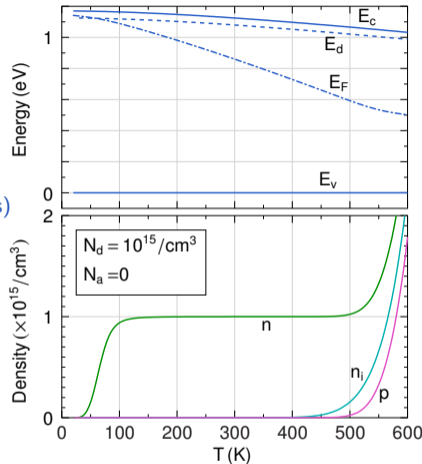
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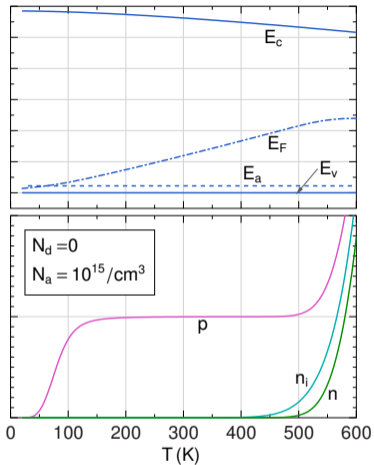
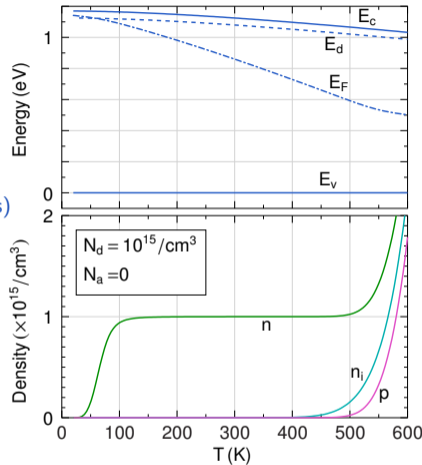
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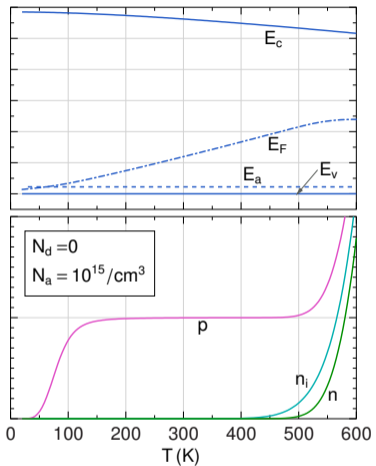
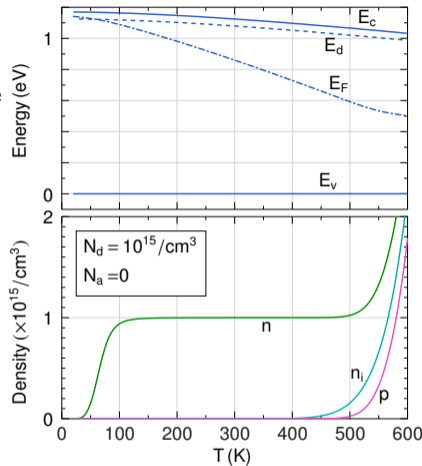
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- * This effect is called the carrier “freeze-out” effect, and it can be a limiting factor in low-temperature operation of semiconductor devices.



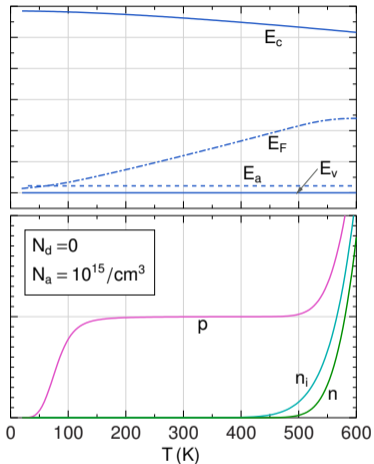
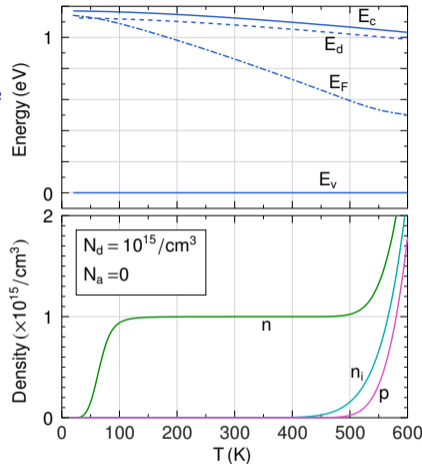
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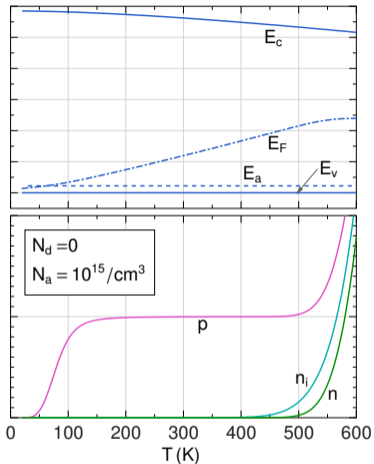
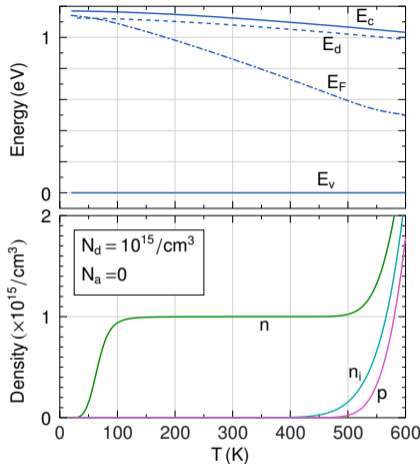
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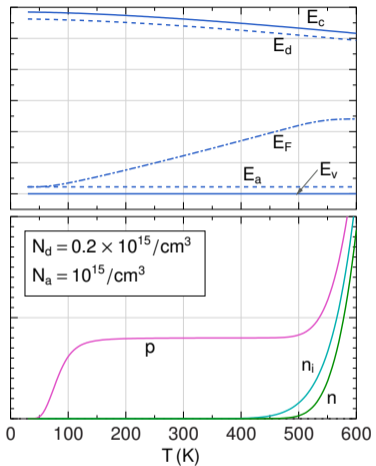
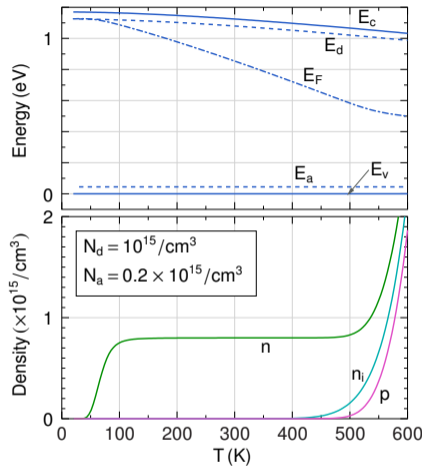
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- * This region is called the “intrinsic region,” and it must be avoided for a semiconductor device to work as intended.



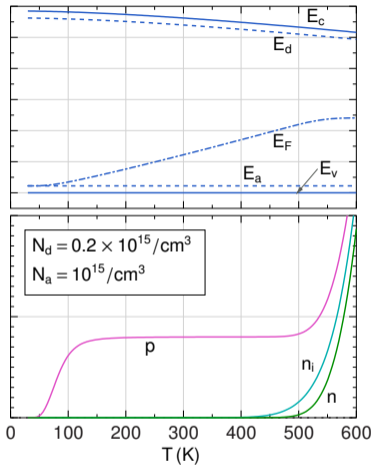
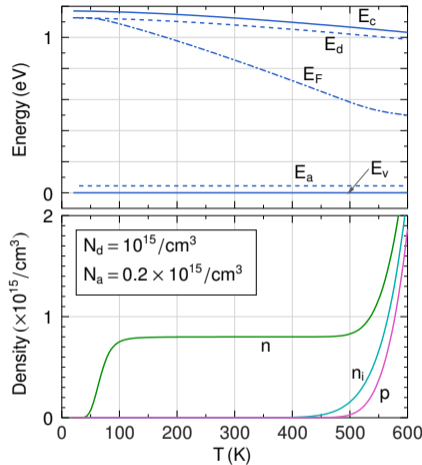
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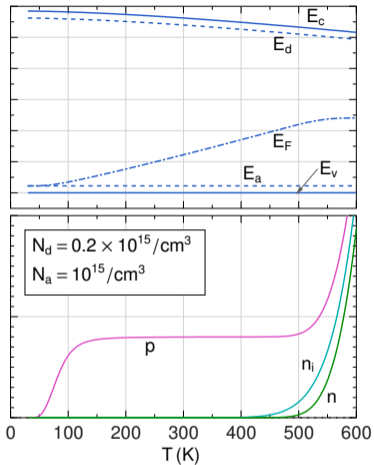
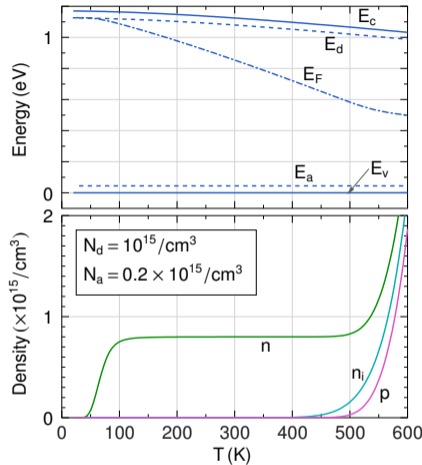
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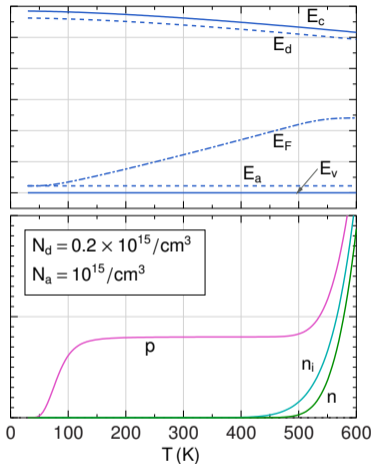
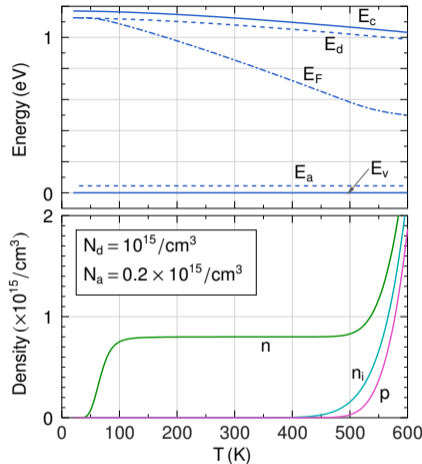
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$$\begin{aligned}np &= N_c e^{-(E_c - E_F)/kT} \times N_v e^{-(E_F - E_v)/kT} \\ &= N_c N_v e^{-(E_c - E_v)/kT} \\ &= N_c N_v e^{-E_g/kT} \\ &= n_i^2(T).\end{aligned}$$

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* The above two equations can be solved to obtain n and p .

Computation of n and p at room temperature in equilibrium: example

In a silicon sample with $N_d = 5 \times 10^{16} \text{ cm}^{-3}$, find the equilibrium electron and hole concentrations at $T = 300 \text{ K}$ ($n_i = 10^{10} \text{ cm}^{-3}$ at 300 K).

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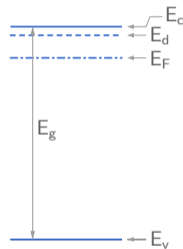
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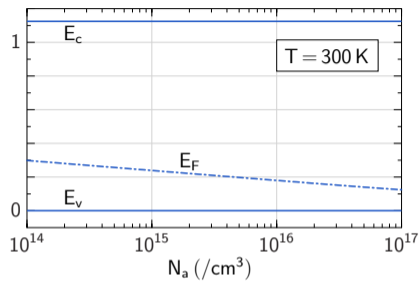
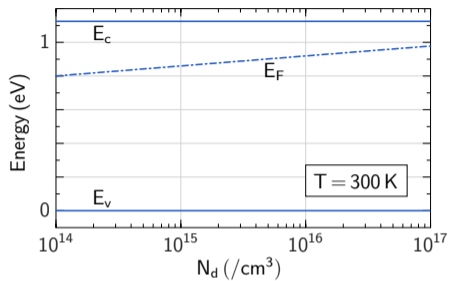
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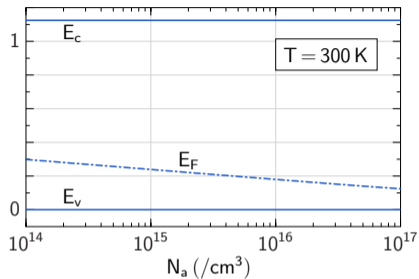
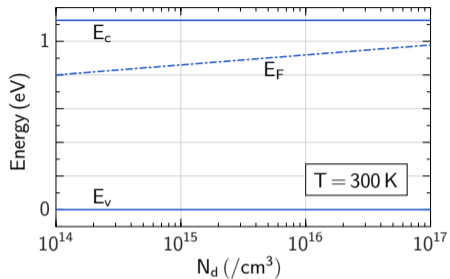
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Variation of E_F with doping density (silicon, 300 K)

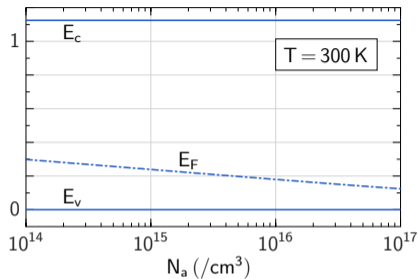
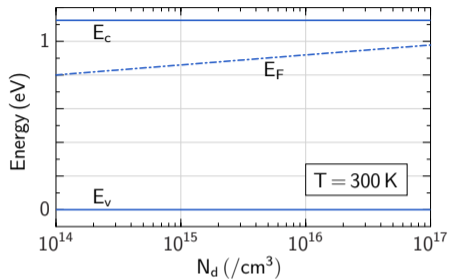


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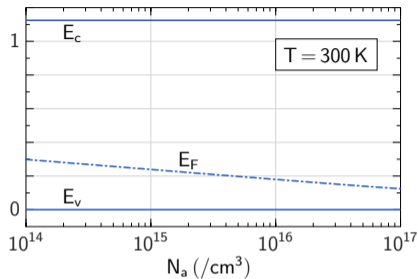
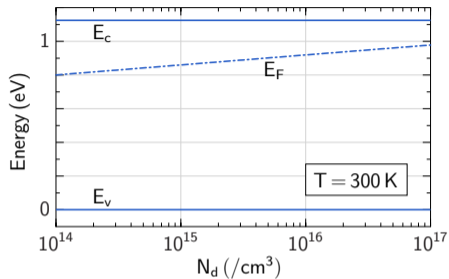
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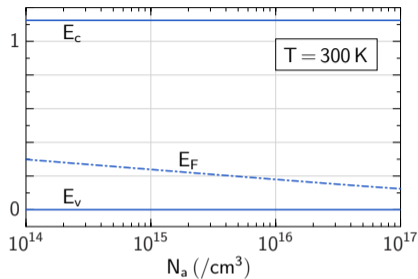
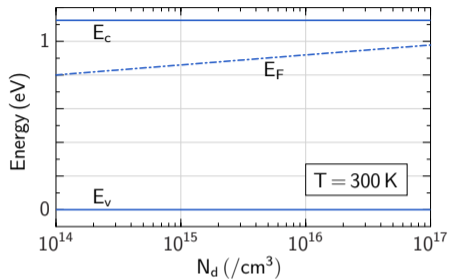
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